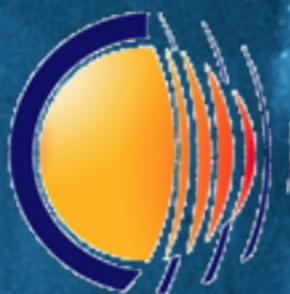


# A plasma source for laser-plasma accelerators

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INSTITUTO DE PLASMAS  
E FUSÃO NUCLEAR

ipfn

# Outline

- ▶ Laser-plasma accelerators introduction
- ▶ Scaling laws for electron accelerators
- ▶ Initial work at plasma channeling (IST and UCLA)
- ▶ Discharges on structured gas cell as a plasma source for  $e^-$  acc.
- ▶ DC discharge for plasma smoothing
- ▶ 8 cm plasma channel status
- ▶  $e^-$  beam injection on plasma channels
- ▶ Conclusions

# Where is the mark on the LPA roadmap ?

## ▶ 2004 - mono-energetic $e^-$ beams demo

- ▶ S.P.D. Mangles et al., Nature 431, 535 (2004), C.G.R. Geddes et al., Nature 431, 538 (2004), J. Faure et al., Nature 431, 541 (2004)

## ▶ 2006 - 1 GeV mono-energetic beam demo

- ▶ W. P. Leemans et al., Nature Phys. 2, 696 (2006)

## ▶ 2006 - some injection control

- ▶ J. Faure, et al., Nature 444, 737 (2006)

## ▶ 2007 - scaling laws for LPA's

- ▶ W. Lu, et al., Phys. Rev. ST Accel. Beams 10, 061301 (2007)

## ▶ 2006 - some applications

- ▶ electron radiography, S. P. D. Mangles, et al., Laser and Particle Beams, 24 (1), pp. 185 (2006)
- ▶ visible light by periodic B, H. P. Schlenvoigt, et al., Nature Physics 4, 130 (2008)
- ▶ UV light by periodic B, M. Fucks, et al., Nature Physics 5, 226 (2009)
- ▶ ...

# Scaling laws for laser-plasma accelerators \*

## Three main regimes

### ▶ Bubble

- ▶ electrons move faster than laser
- ▶ for  $n_e = 10^{19} \text{ cm}^{-3}$  requires  $a_0 = 20$  or  $I = 2 \times 10^{21} \text{ W cm}^{-2}$

$$a_0 \geq \sqrt{2 \frac{n_c}{n_p}}$$

for circ. pol. laser,  
for lin. pol laser is 1.4 times higher

$$\Delta E [\text{GeV}] \simeq 0.018 \frac{P [\text{TW}]}{a_0}$$

### ▶ Blowout - self-guiding

- ▶ intensity enough for relativistic guiding  $P > P_c$
- ▶ matched beam spot size condition  
 $k_p R = k_p w_0 = 2 (a_0)^{0.5}$
- ▶ requires  $a_0 > 3-4$  for injection

$$a_0 \simeq \left( \frac{P}{P_c} \right)^{1/3}$$

$$\Delta E [\text{GeV}] \simeq 0.16 \frac{P [\text{TW}]}{a_0^2}$$

### ▶ Blowout - external-guiding

- ▶ intensity enough for electron cavitation
- ▶ requires preformed plasma channel
- ▶ requires an external injection mechanism

$$a_0 = 2$$

\* W. Lu, et al., Phys. Rev. ST Accel. Beams 10, 061301 (2007)

# Example: scaling for ELI

		Laser energy on target	100 mJ	1 kHz	1.5J 100 Hz	45 J 10 Hz
Blowout	Self guiding	$\tau$ [fs]	9.8	24.2	65.8	
		$W_0$ [ $\mu\text{m}$ ]	4.4	10.9	29.6	
		$n_e$ [ $10^{19} \text{ cm}^{-3}$ ]	23.2	3.83	0.63	
		L [mm]	0.2	3.3	54.6	
		$\Delta E$ [GeV]	0.1	0.62	4.59	
		Q [nC]	0.13	0.31	1.04	
	External guiding	$\tau$ [fs]	15.6	38.4	119.2	
		$W_0$ [ $\mu\text{m}$ ]	7.0	17.3	53.7	
		$n_e$ [ $10^{19} \text{ cm}^{-3}$ ]	4.62	0.76	0.08	
		L [mm]	1.8	26.4	793.1	
		$\Delta E$ [GeV]	0.26	1.56	15.06	
		Q [nC]	0.1	0.25	0.78	
Bubble	$\tau$ [fs]	6.6	12.2	26.8		
	$W_0$ [ $\mu\text{m}$ ]	2.0	3.7	8.1		
	$n_e$ [ $10^{19} \text{ cm}^{-3}$ ]	57.3	24.92	8.74		
	L [mm]	0.03	0.2	1.8		
	$\Delta E$ [GeV]	0.03	0.18	1.5		
	Q [nC]	0.55	1.54	5.71		

# Medium-long term e- beam development

## ▶ Laser

- ▶  $20 \text{ fs} < \tau < 120 \text{ fs}$ ,  $1 \text{ J} < E < 50 \text{ J}$ , high stability, (current tech solution: diode pumped Ti: sapphire CPA chain)

## ▶ Plasma channel

- ▶  $10^{17} \text{ cm}^{-3} < n_{e \text{ axis}} < 5 \times 10^{18} \text{ cm}^{-3}$ ,  $1 \text{ cm} < L < 1 \text{ m}$

## ▶ Injection (beam loading)

- ▶ self injection or colliding beams ( $dE/E < 1\%$ )
- ▶ double stage or other scheme

## for application needing...

- ▶ short pulses and high currents: Free-Electron-Lasers (seeding required)
- ▶ electron beams synch. w/ laser: pump probe experiments
- ▶ compact broadband x and gamma-rays: betatron, Compton scattering, ...

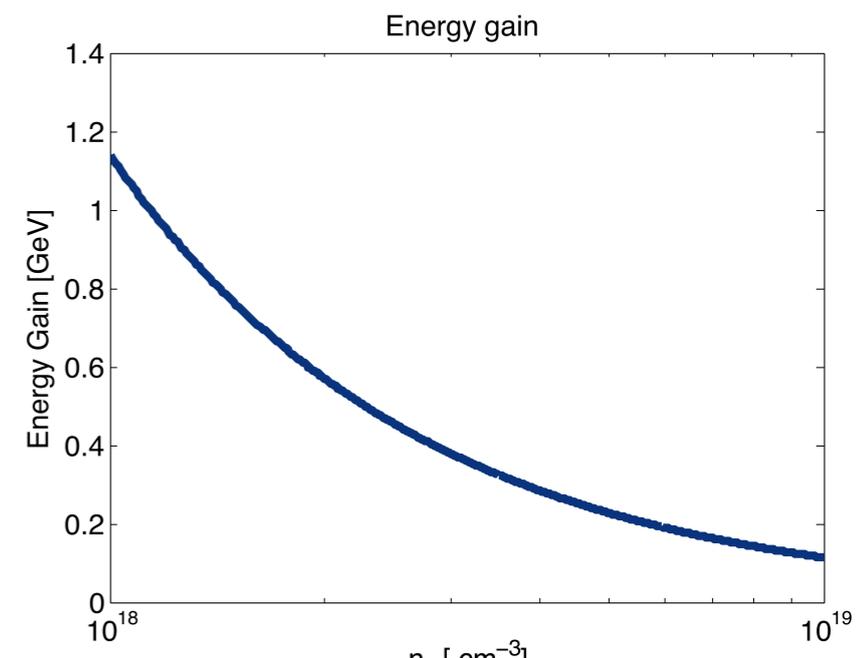
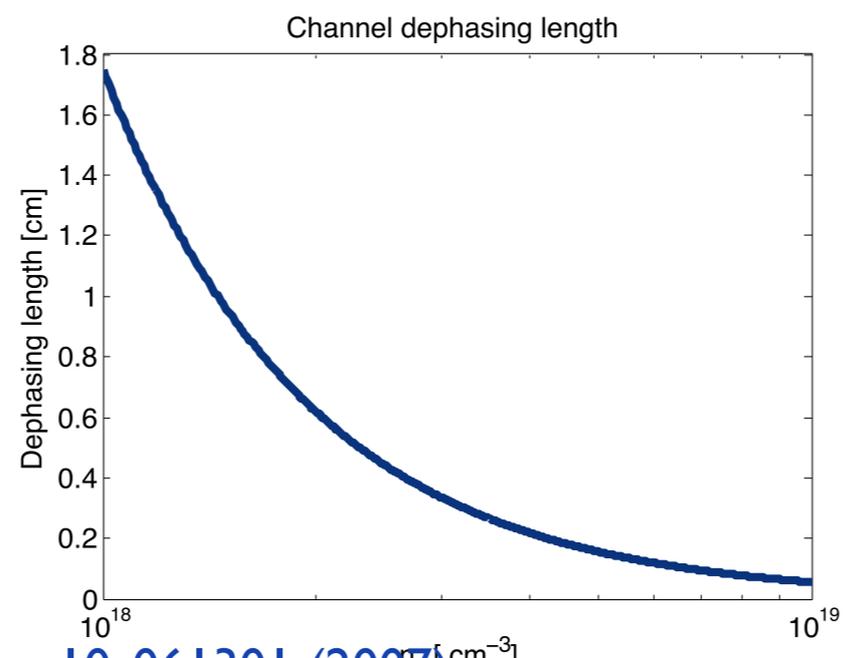
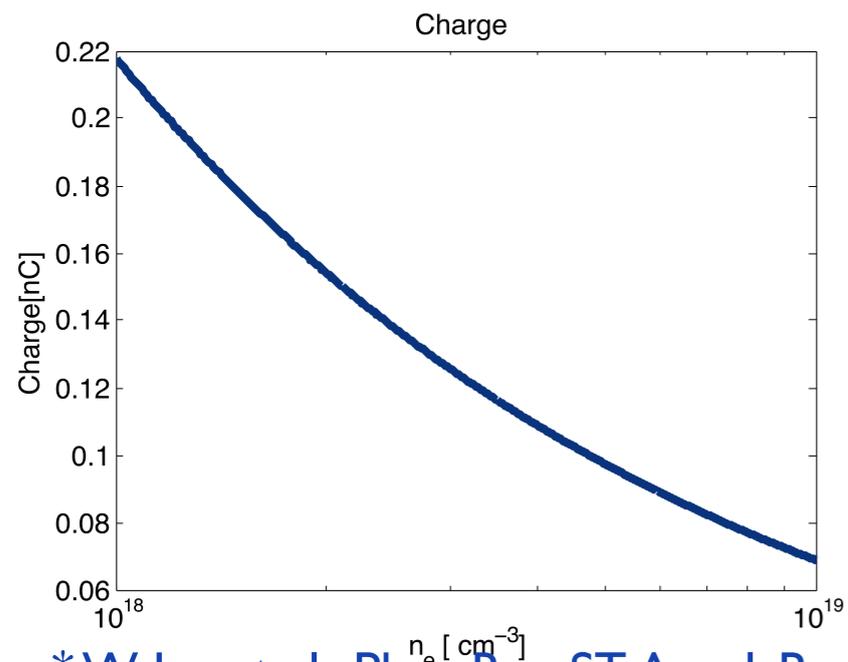
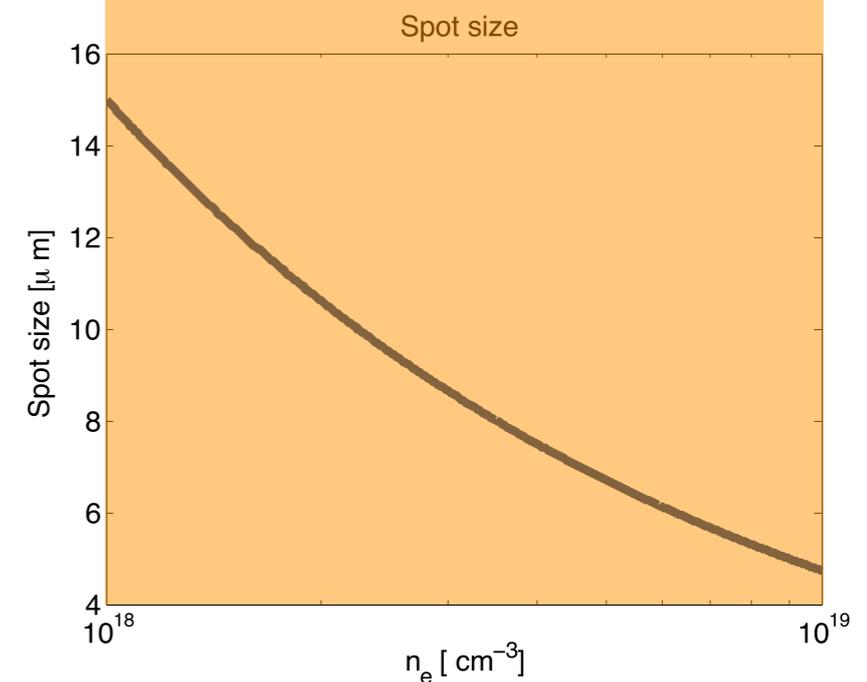
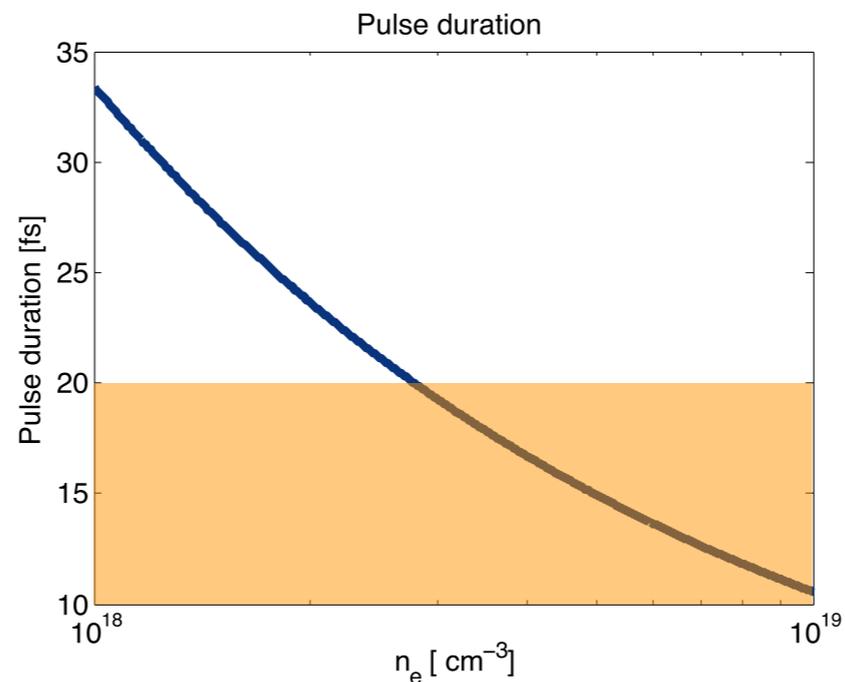
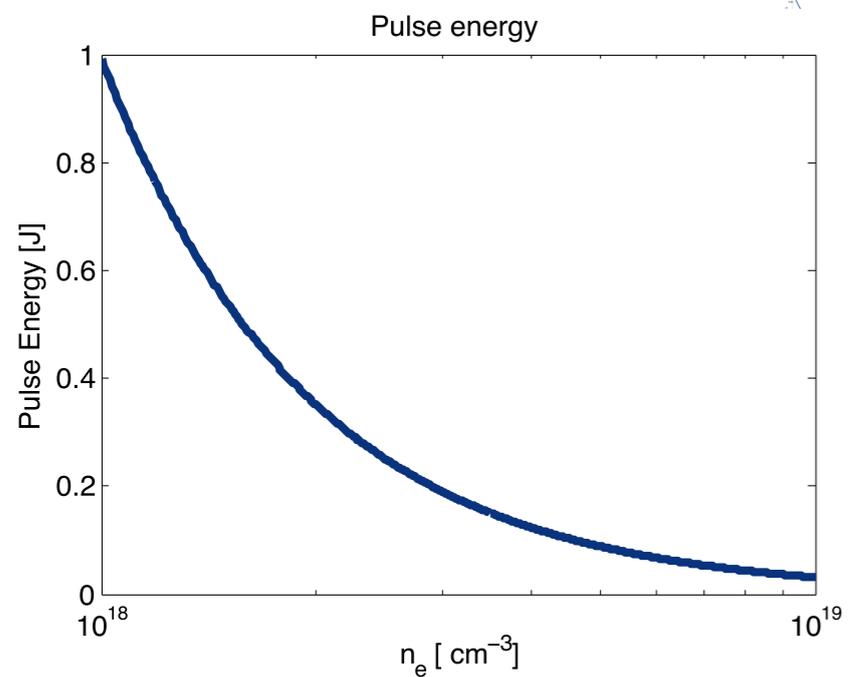
## or tolerating...

- ▶ few percent  $dE/E$
- ▶ beam Coulombian explosion (for high charge & low energy)
- ▶ non reproducible E and low rep. rate

# Scaling laws for external guided high density LPA\*

## assumes

- ▶ matched propagation external guiding
- ▶  $a_0=2$  for electron blowout
- ▶ an external injection mechanism

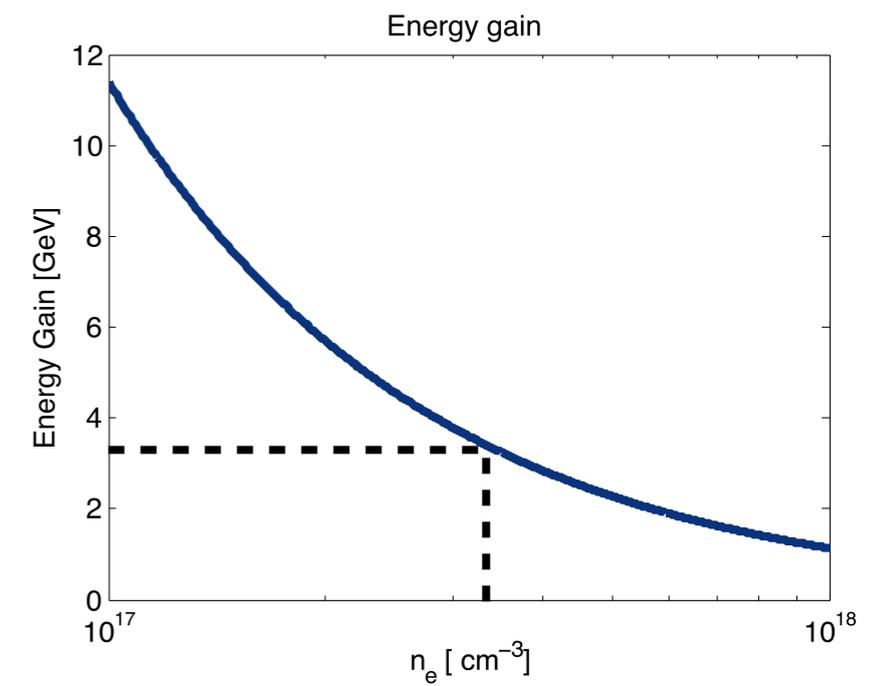
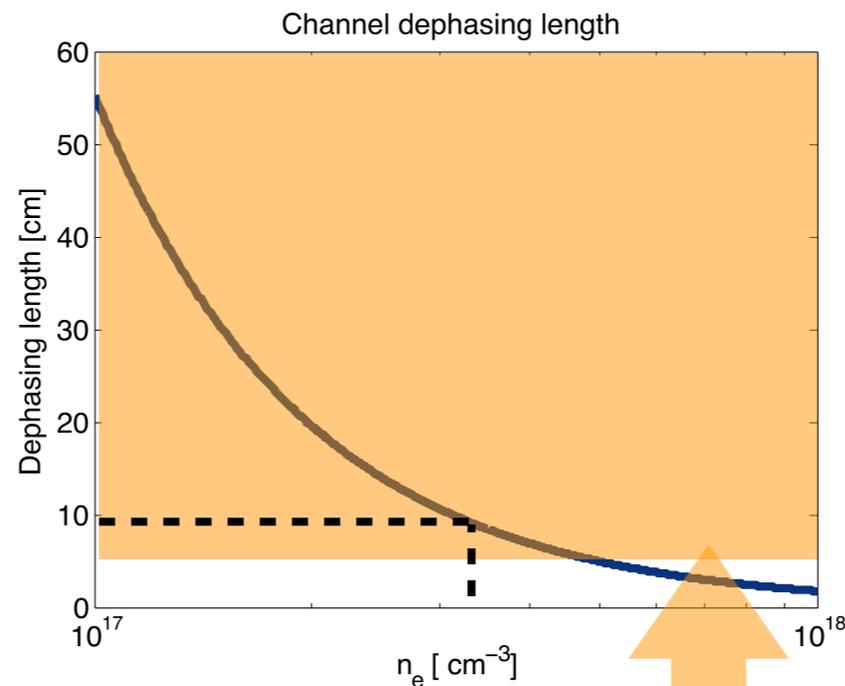
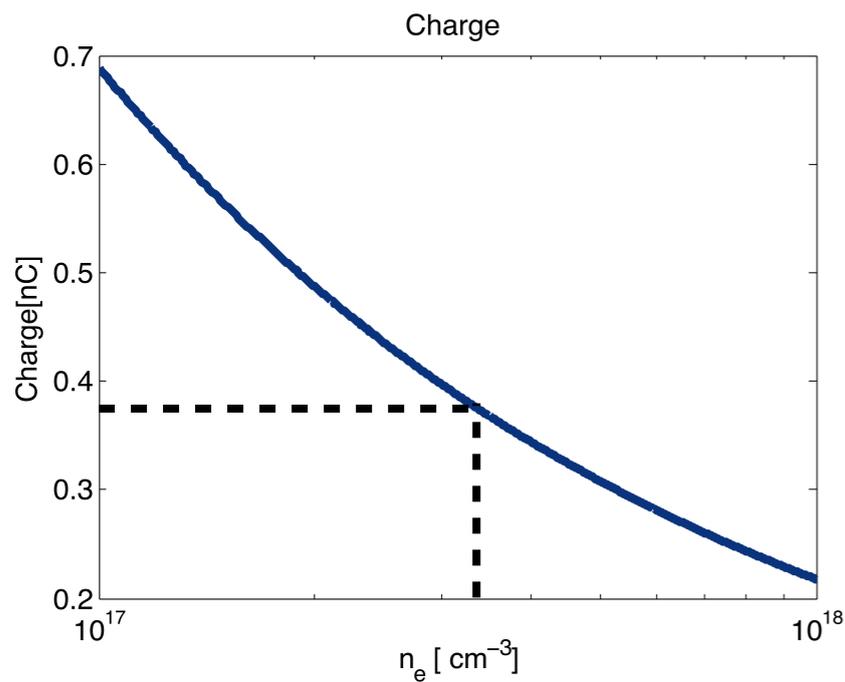
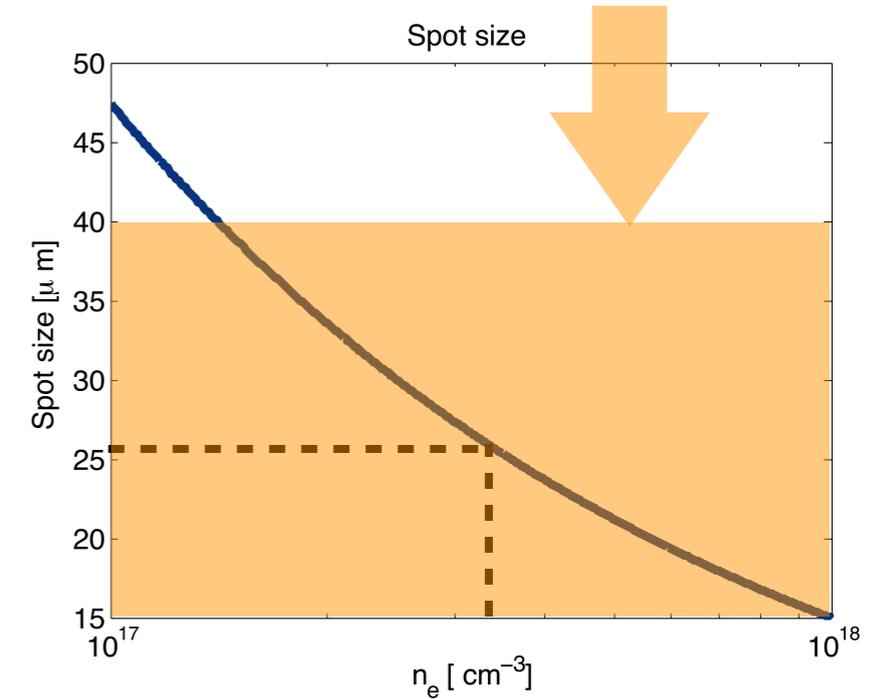
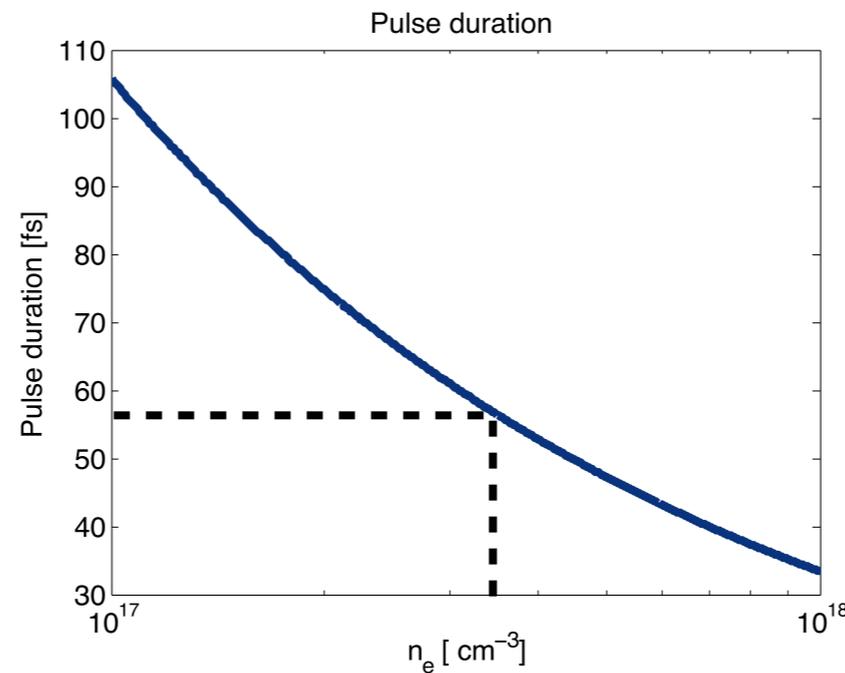
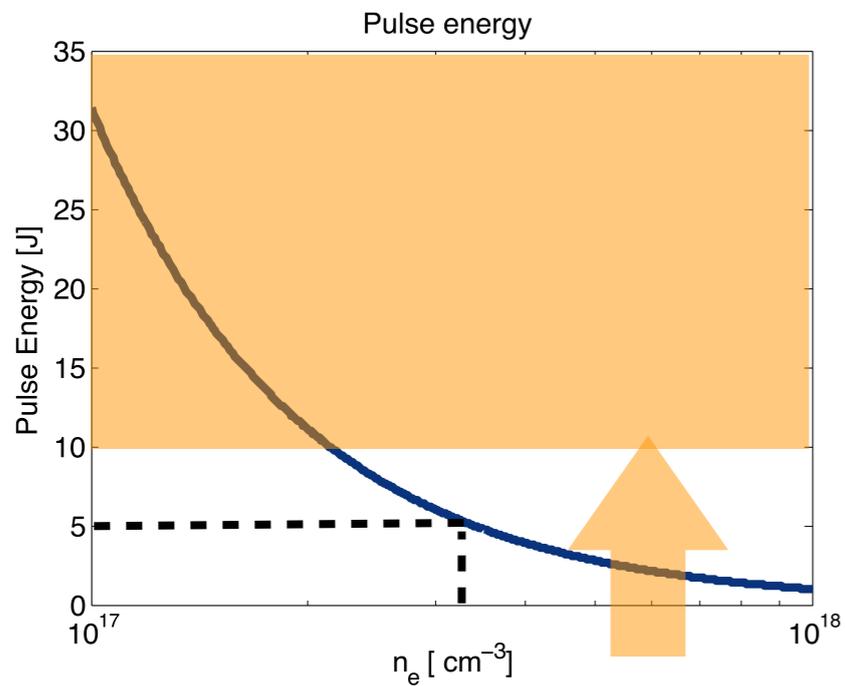


\* W. Lu, et al., Phys. Rev. ST Accel. Beams 10, 061301 (2007)

# Scaling laws for external guided low density LPA

## assumes

- ▶ matched propagation external guiding
- ▶  $a_0=2$  for electron blowout
- ▶ an external injection mechanism



# IST experimental program on guiding plasmas

Plasma channels development started at IST in 2001

Why?

Initial motivation

- ▶ Decrease laser power for SM-LWFA
- ▶ Research line not critically dependent of laser
- ▶ Long term research program leading to proprietary technology (and economic return)
- ▶ have an electron beam at IST (this was before the monoenergetic beams)

# Low power matched guiding in plasma channels\*

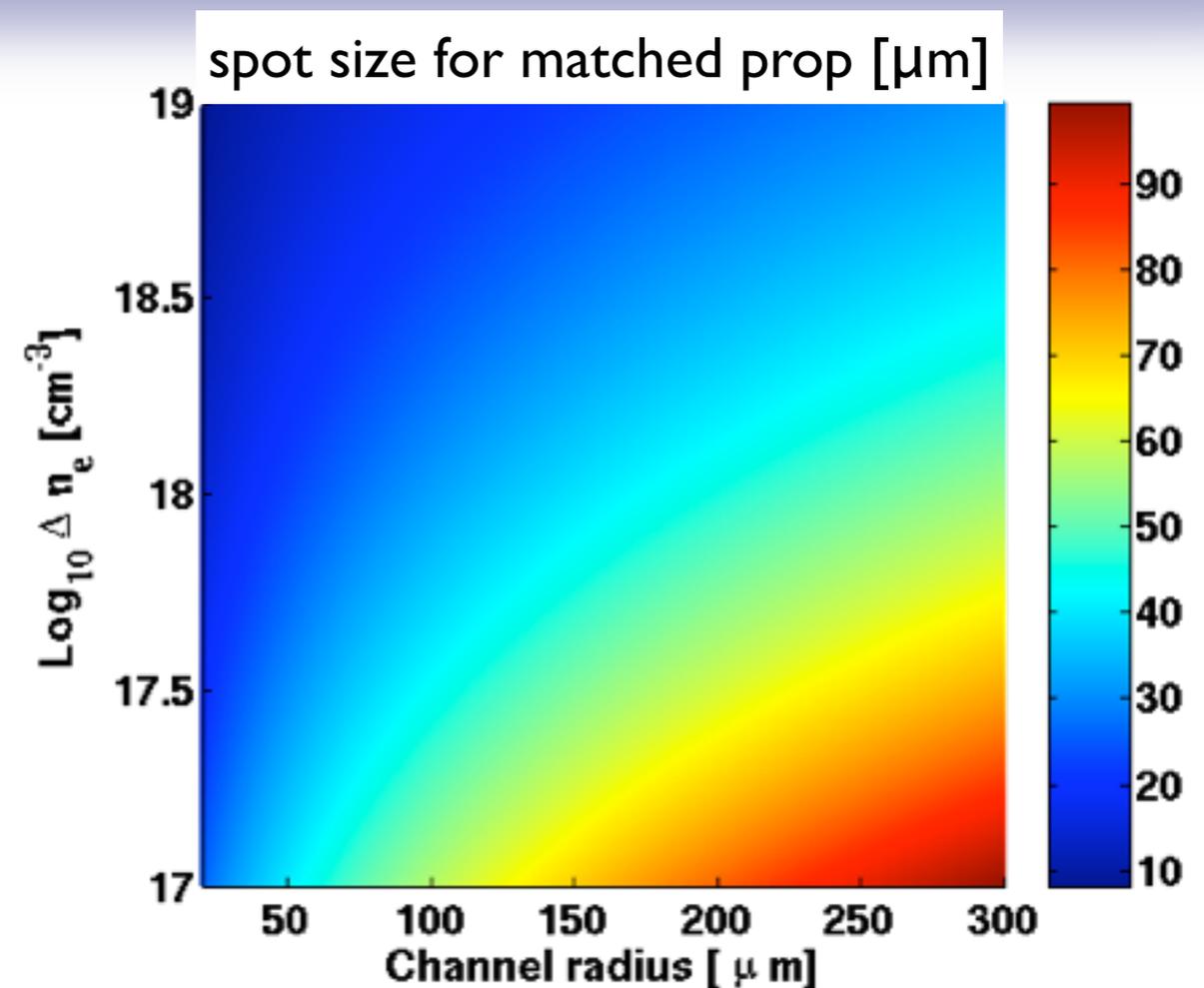
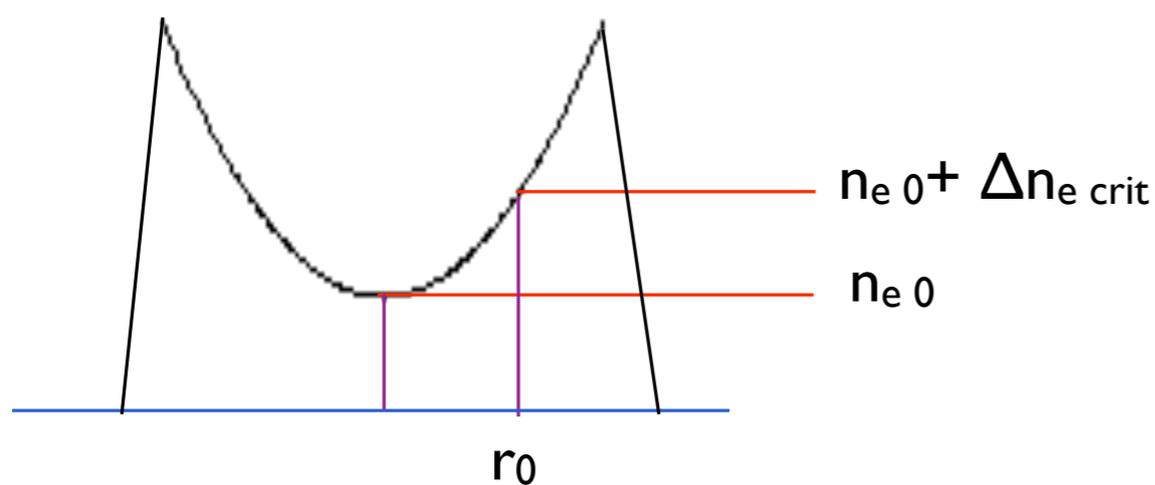
## assumes

- ▶ Gaussian beam
- ▶ Low power ( $a_0 < 1$ )
- ▶ parabolic profile
- ▶ paraxial approximation

$$n_e(r) = n_{e0} + Ar^2$$

$$A = \Delta n_{e \text{ crit}} / r_0^2$$

$$\Delta n_{e \text{ crit}} = 1.1 \times 10^{20} / r_0^2 [\mu\text{m}]$$



\* E. Esarey, et al., IEEE Trans. Plasma Sci. 24, 252 (1996)

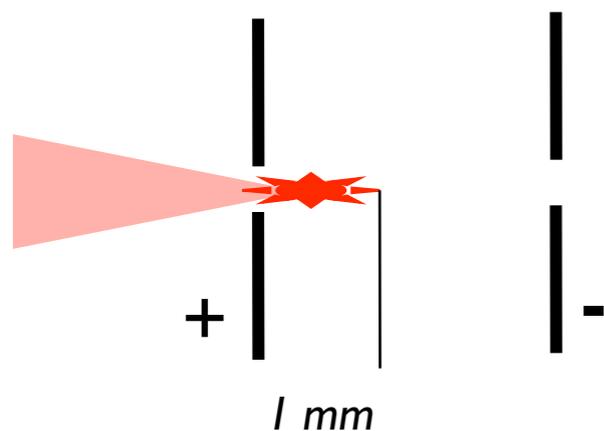
# Early 2000's work on laser channeling (some)

- ▶ J. Roca's, U. Colorado - work on x-ray lasers in capillary discharges
- ▶ H. Milchberg, U. Maryland - plasma channels created in gases by focusing a laser w/ a conical lens (a)
- ▶ Y. Ehrklich, Jerusalem U. - plasma channels by ablation of plastic capillaries using HV discharges (b)
- ▶ Gaul, Texas U. - plasma channels by heating a plasma created by laser w/ conic lens
- ▶ S. Hooker, Oxford U. - plasma channels by a discharge in a capillary filled with H<sub>2</sub> (c)

# New method: free expansion plasma channels\*

## ▶ Helium ionization

- ▶ Gap  $\approx 1$  cm
- ▶ helium working pressure  $\approx 100 - 500$  mbar  $\approx 5 \times 10^{18}$  cm $^{-3}$
- ▶ Voltage = 20 kV
- ▶ Electron mean energy  $\approx 15$  eV
- ▶ helium ionization potentials  $U1=24.6$  eV,  $U2=54.4$  eV

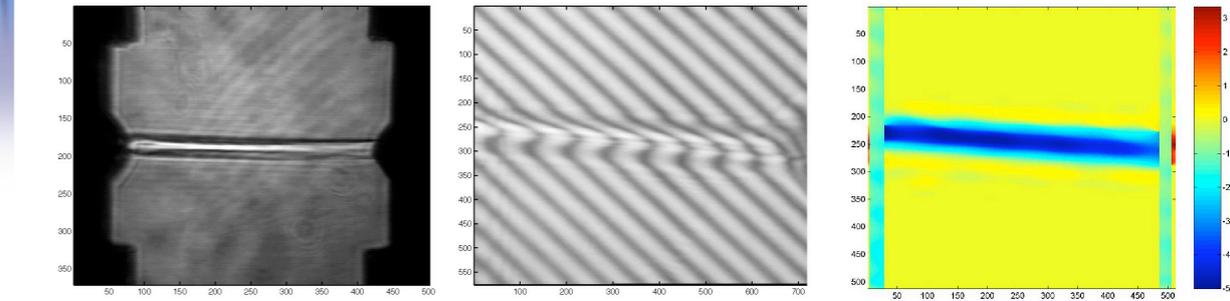
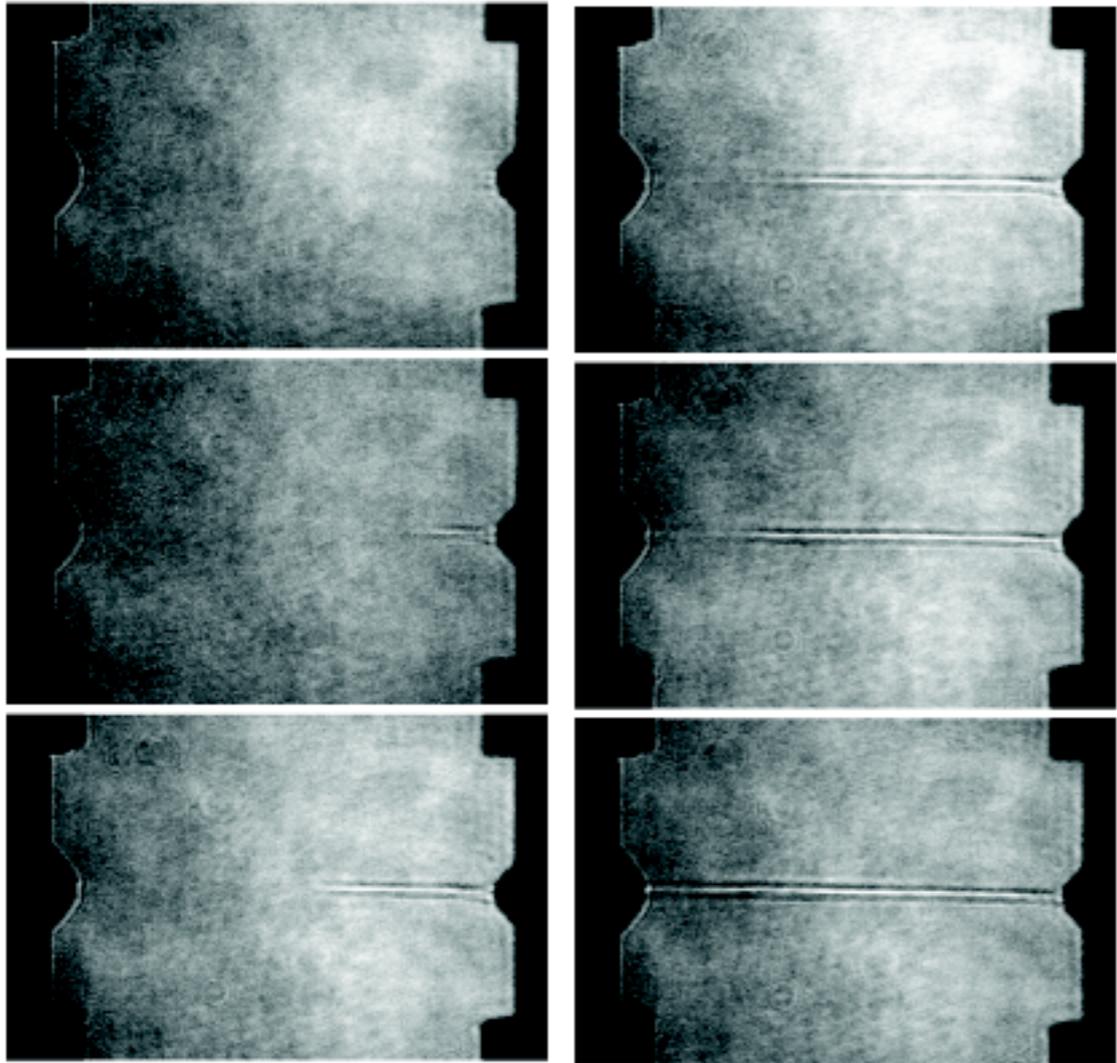


## ▶ Intense laser triggering

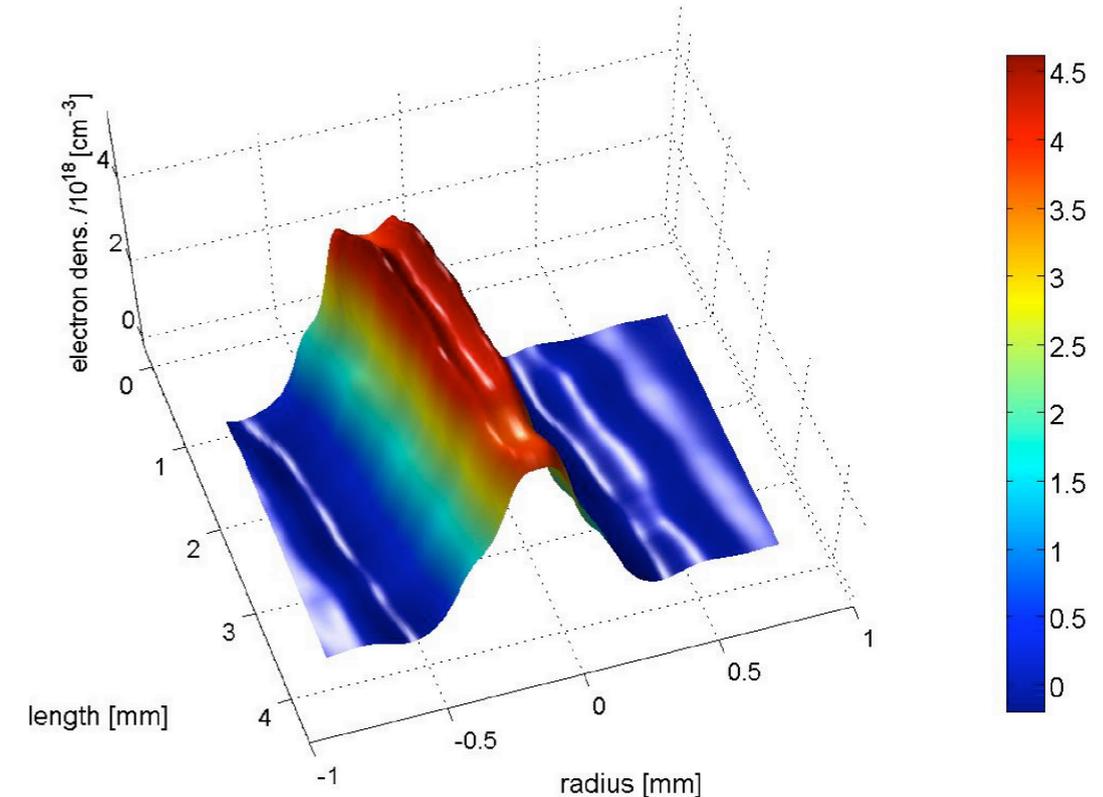
- ▶ Laser creates about 1 mm of fully ionized plasma
- ▶ Electric field accelerates electrons to  $> 1$  keV
- ▶ Laser triggering allows
  - ▶ Fast ionization
  - ▶ Straight plasmas
  - ▶ No jitter

\*“Plasma channels produced by a laser-triggered high-voltage discharge”,  
N. C. Lopes et al., Phys. Rev. E. 68, 035402 (2003)

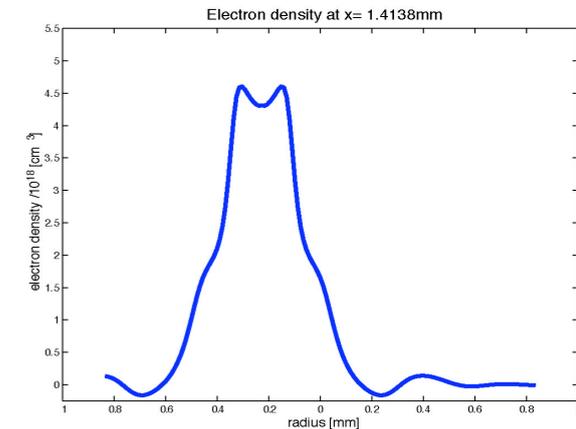
# Demonstration of channeling formation



Electron density



- ▶ Reproducible reproduction of straight plasma lines  $\phi = 150 \mu\text{m}$
- ▶ Development of high density ( $> 5 \times 10^{18} \text{ cm}^{-3}$ ) parabolic plasma channels
- ▶ Experiment too difficult, scheme ok for lab with two lasers
- ▶ Free expansion seems to work well



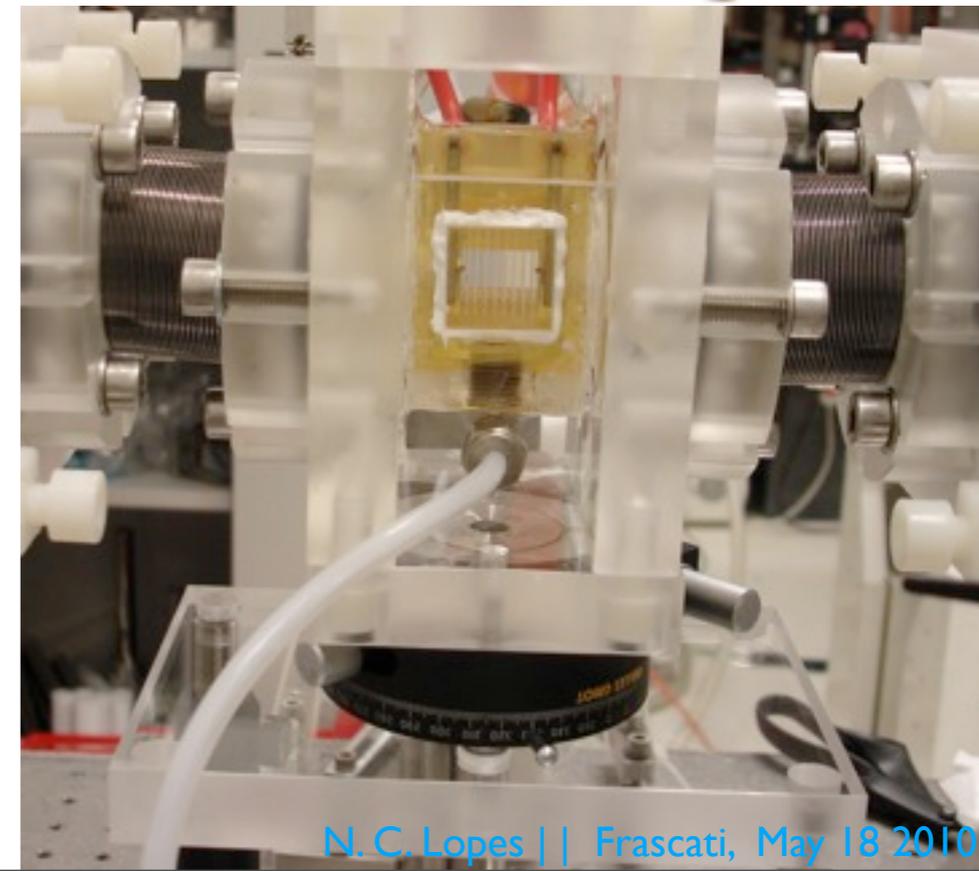
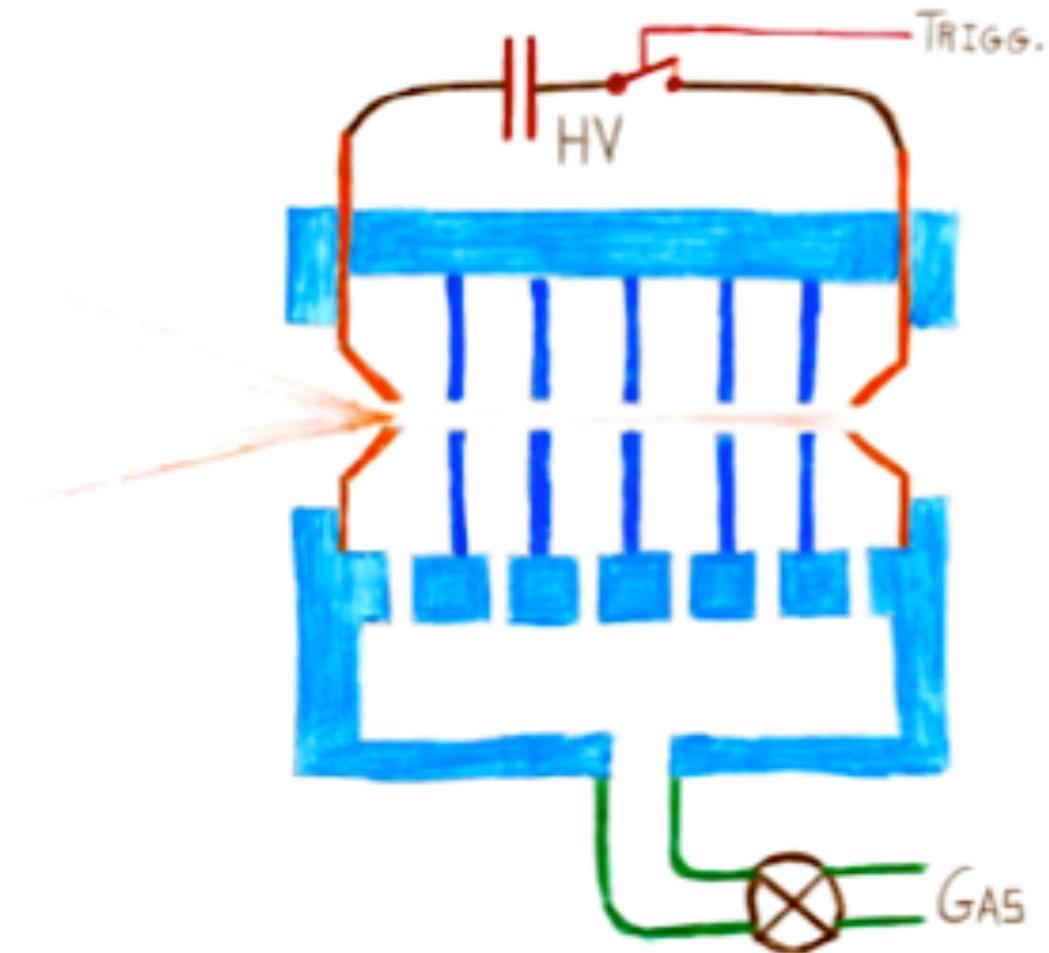
# Discharges on structured gas cells - IST 2006

## ► Why

- (almost) free radial expansion
- no laser triggering of discharge
- fast gas filling (reduced leak compared with capillary)
- different zones of pressure/gas composition

## ► How

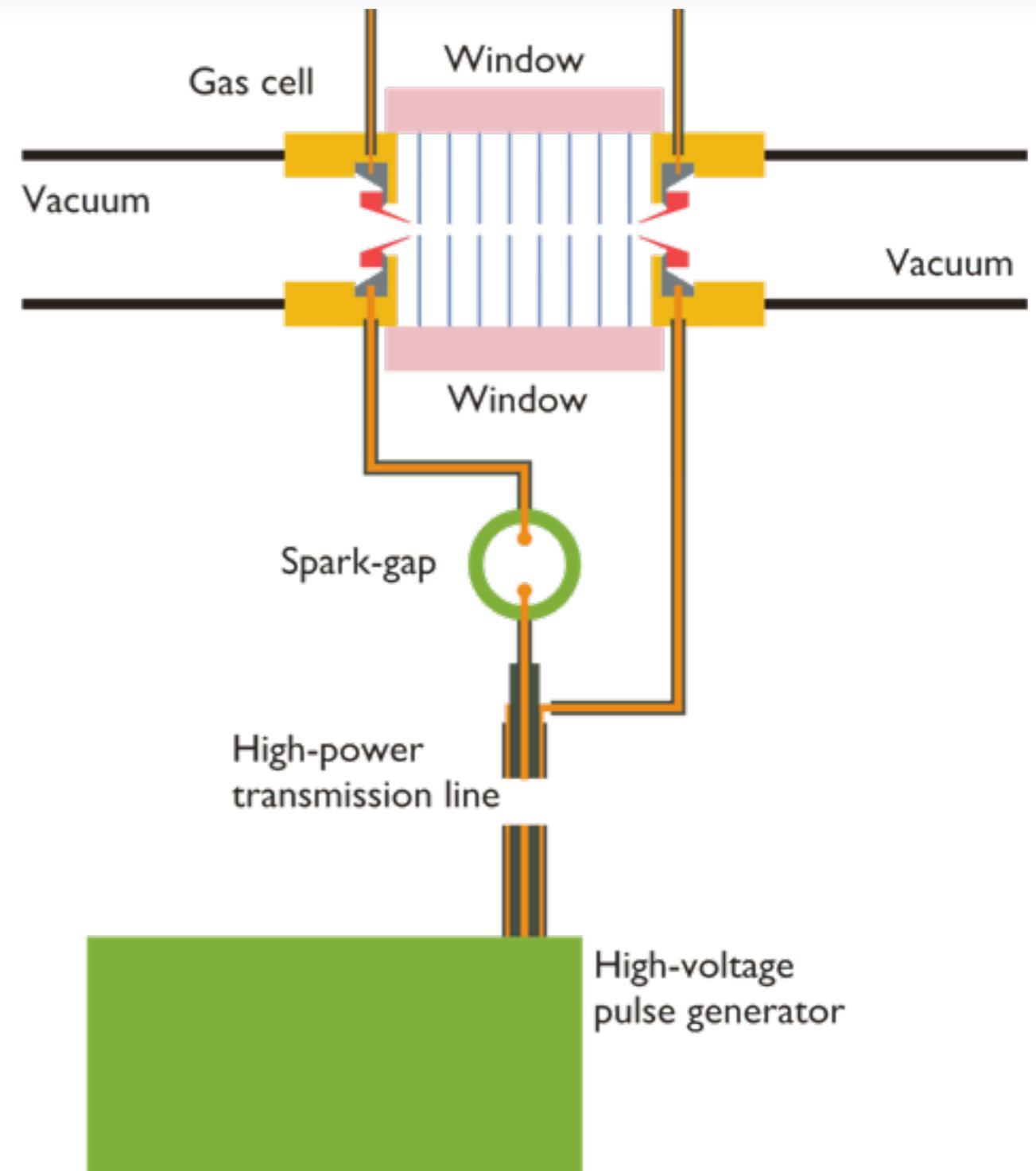
- hollow conic electrodes + sequence of dielectric apertures
- use a short rise-time high-voltage and current pulse
- use H<sub>2</sub>



# Discharges on structured gas cells - IST 2006

## ▶ Gas cell

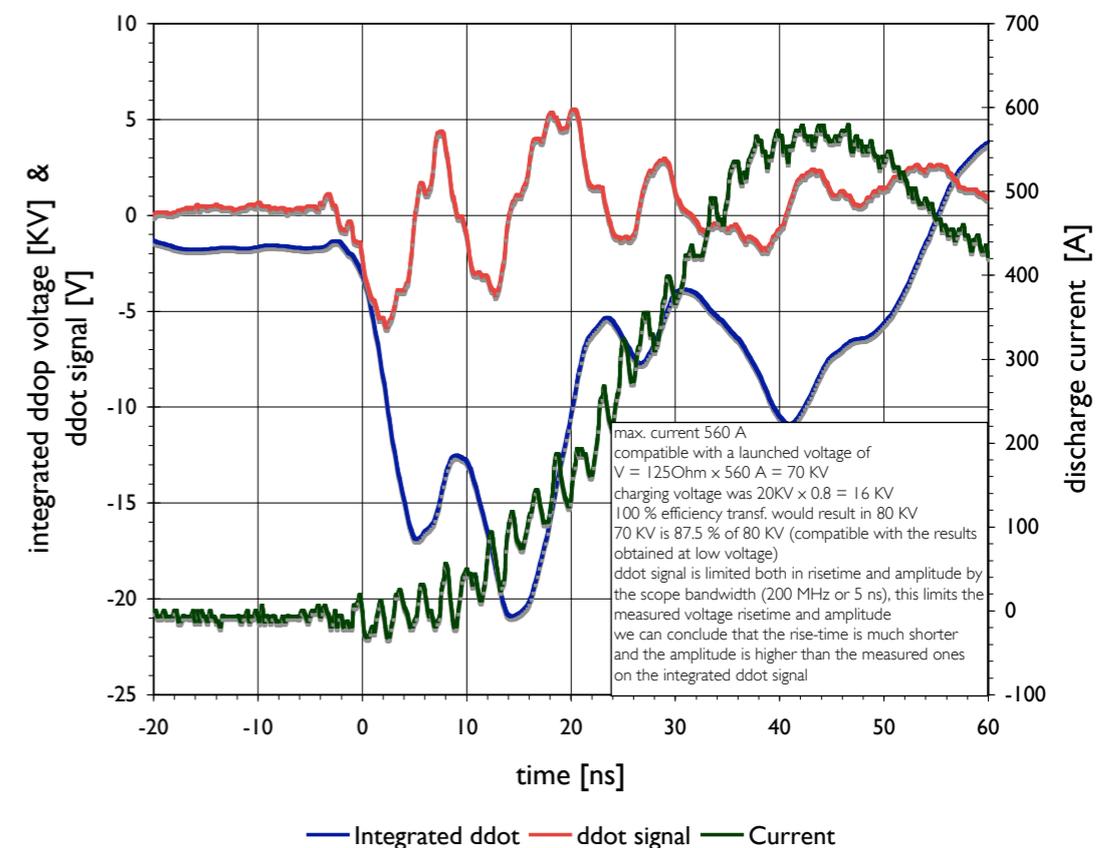
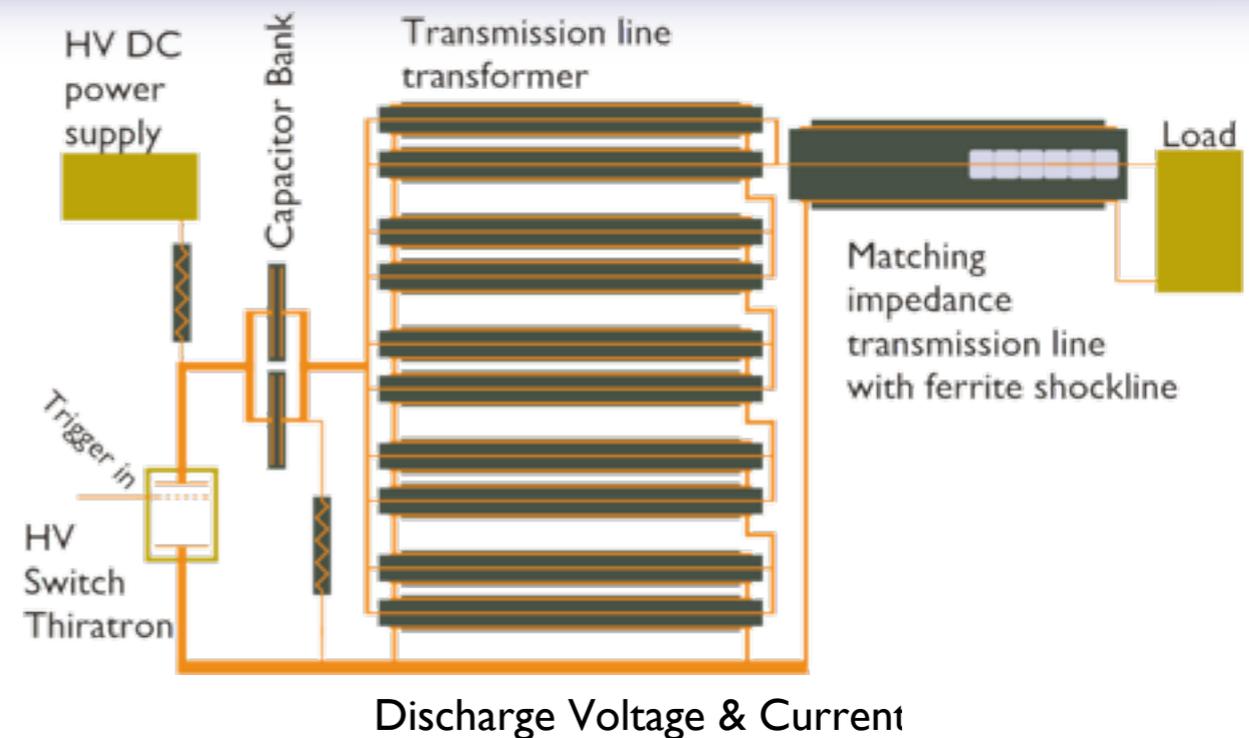
- ▶ 2 cm long, 9 sub-cells
- ▶ copper electrodes
- ▶ dielectric apertures to fix initial plasma size and position
- ▶ aperture diameters 100 - 300  $\mu\text{m}$
- ▶ no laser triggering and radial plasma expansion
- ▶ possibility of different density regions
- ▶ gas injection up to 500 mBar in 10 ms
- ▶ vacuum up to  $10^{-3}$  mbar between shots
- ▶ optical access for diagnostics
- ▶ scalable to multi-GeV energies



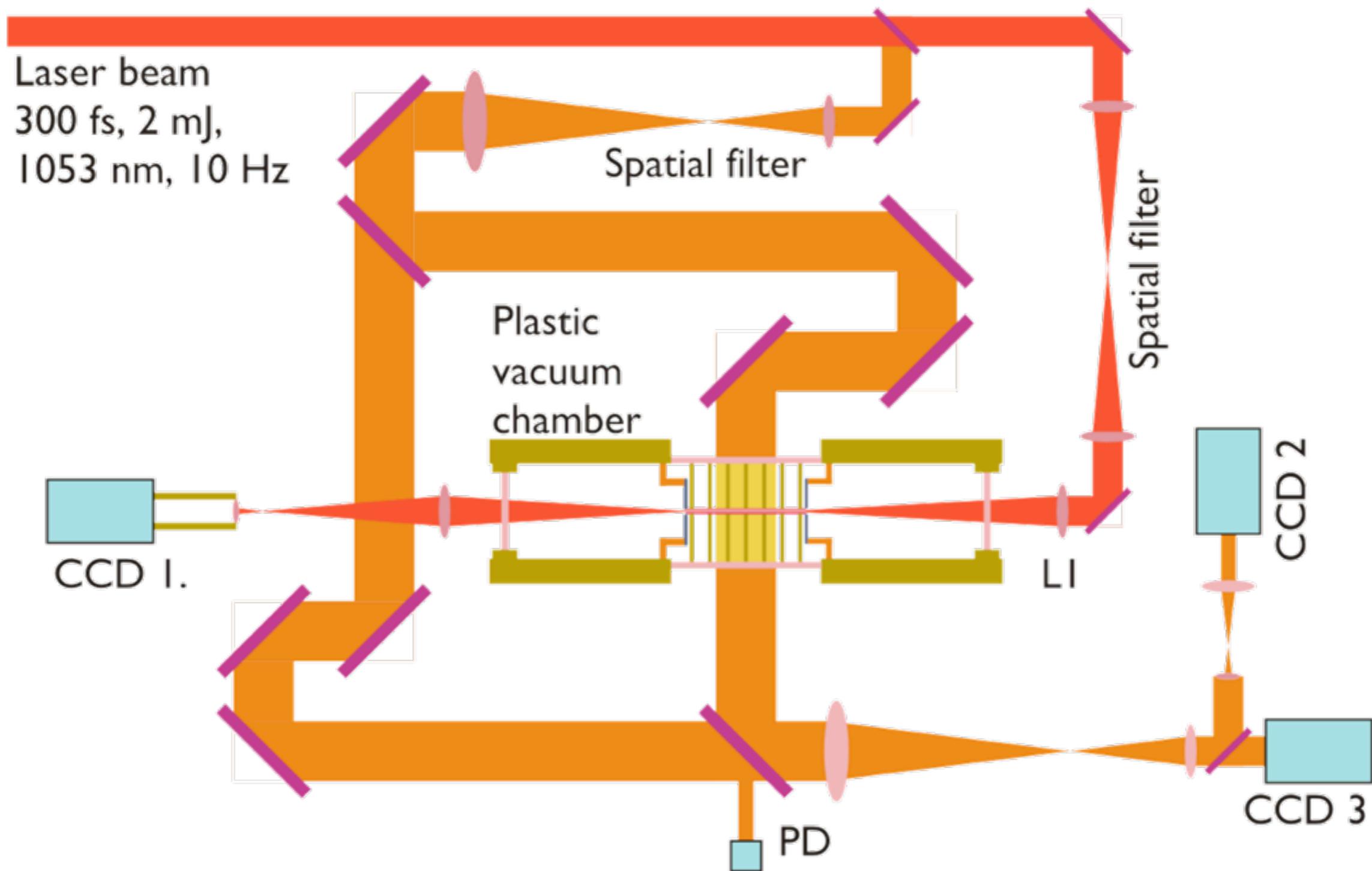
# Structured gas cell: HV pulse generator

## High-voltage pulse generator

- ▶ capacitor discharge (20 kV)
- ▶ pulse transformer (5 x)
- ▶ 125 Ohm output impedance
- ▶ up to 100 kV / 125  $\Omega$  / 1kA pulse
- ▶ rise time:  $\sim 20$  ns
- ▶ duration:  $\sim 200$  ns
- ▶ may use magnetic pulse compression for rise time:  $< 5$  ns
- ▶ synchronization with laser (1 ns jitter)

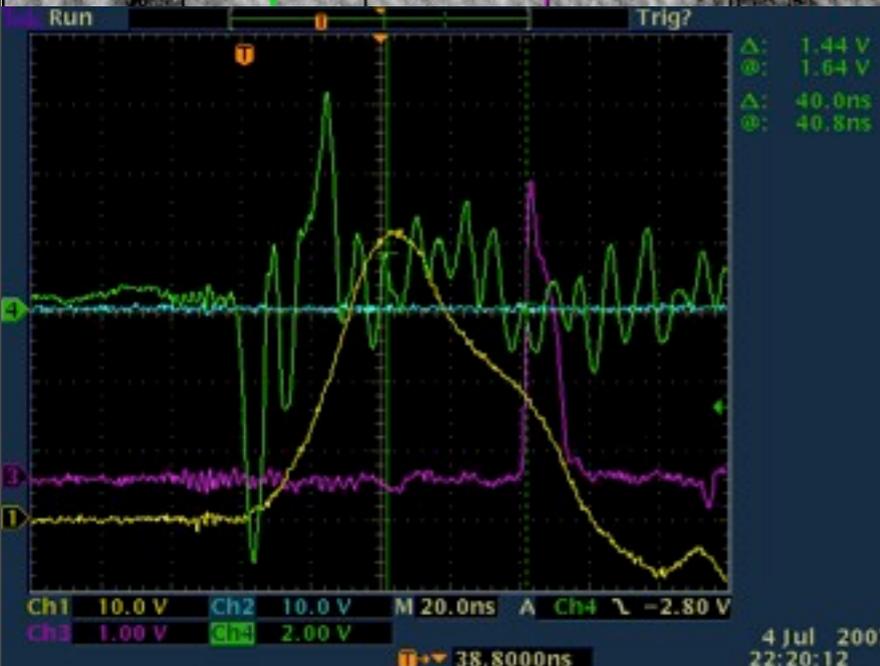
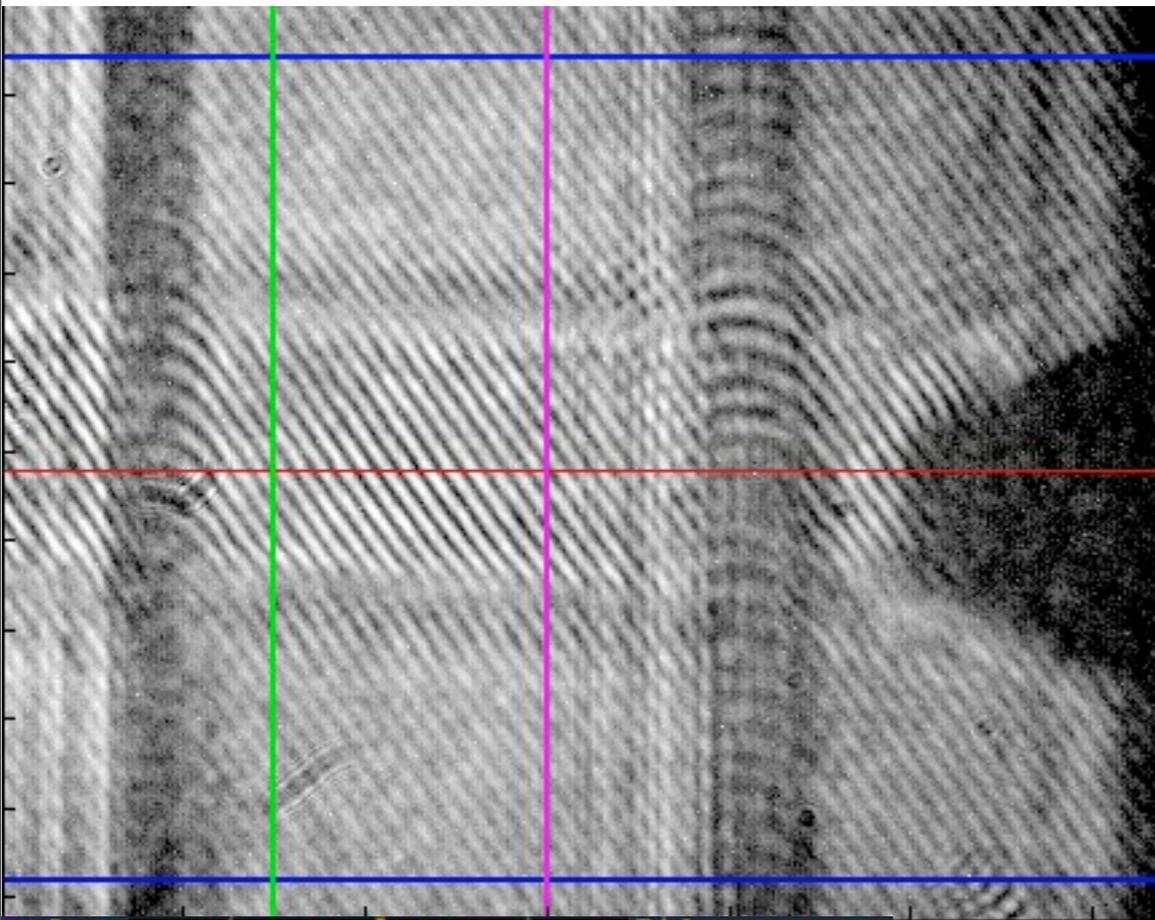


# Schematic of the channel test facility at L2I

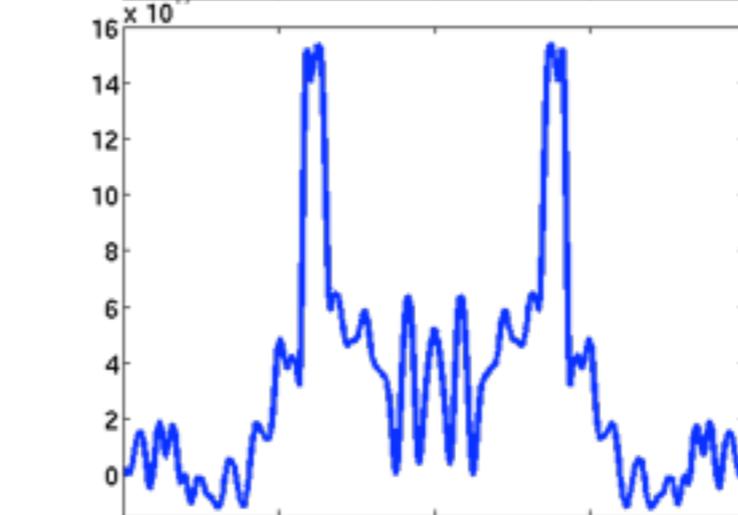
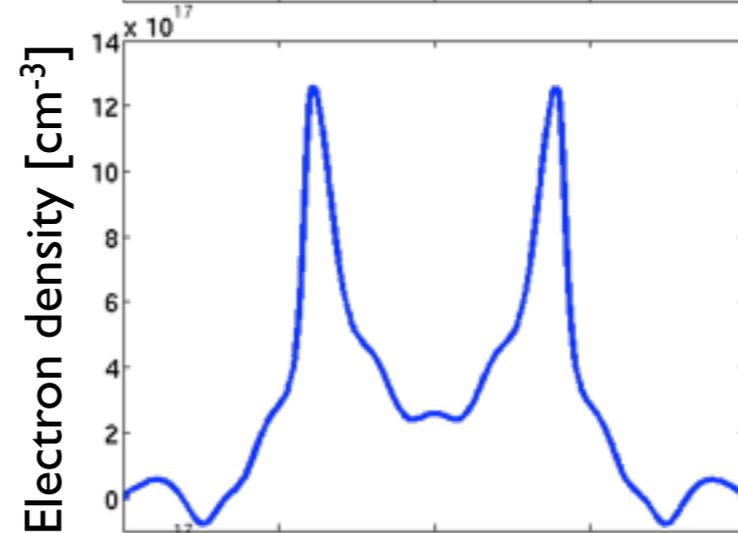
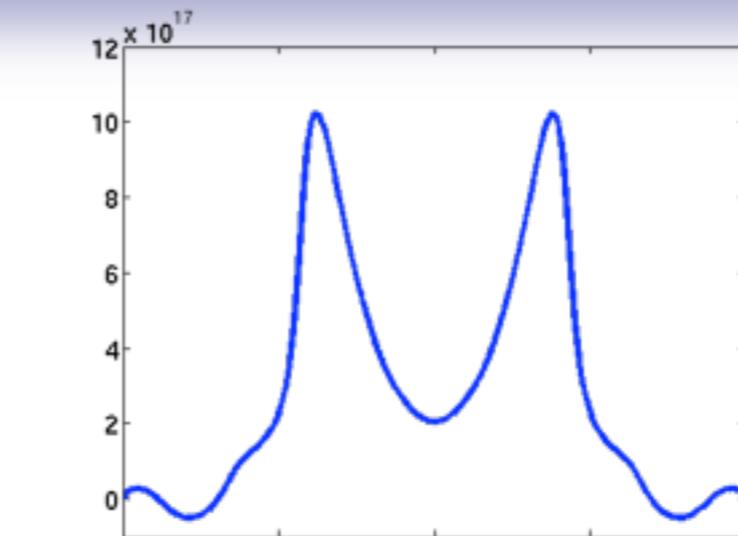


# Experimental results - plasma density profile

## Interferometry

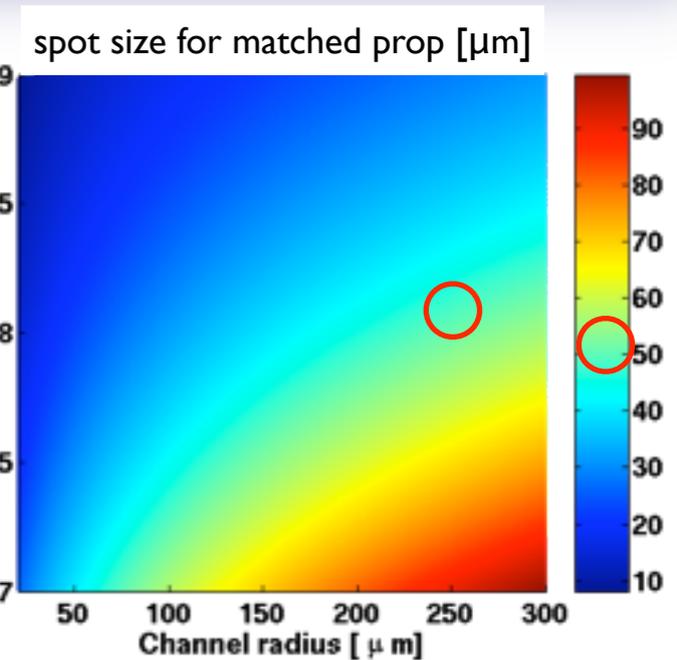


Current  
Laser



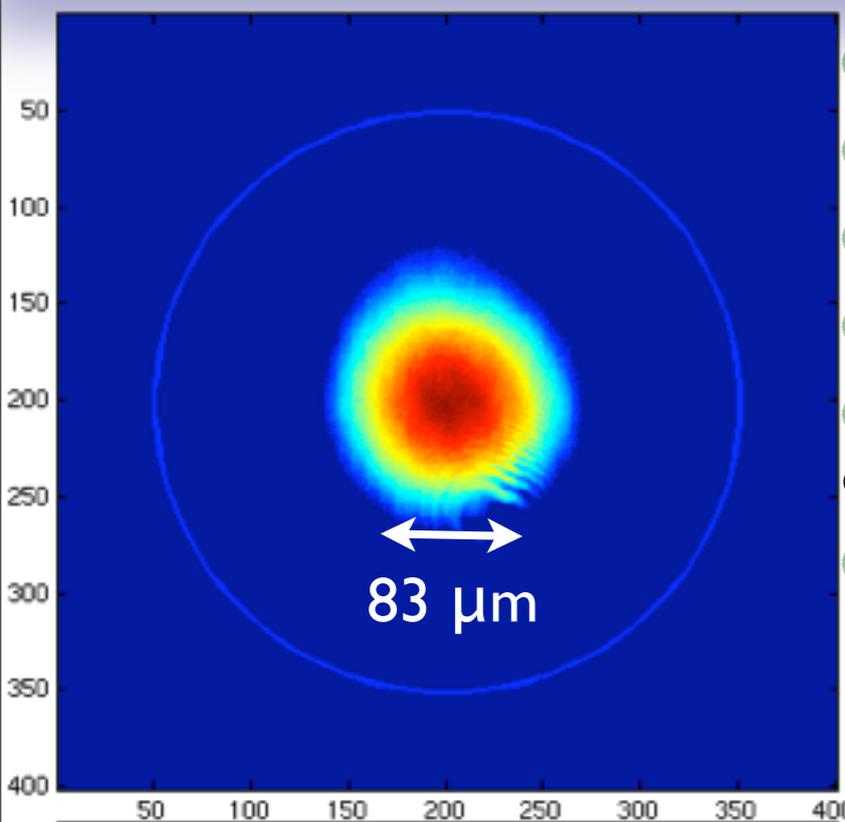
500  $\mu m$

Different filtering

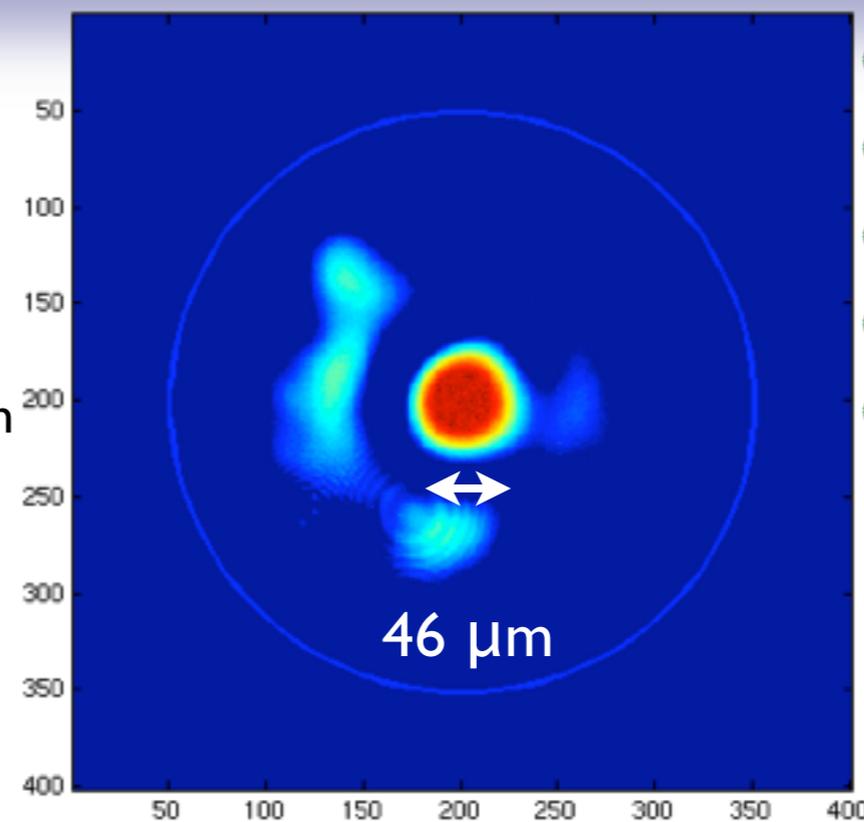


- matched prop. spot radius  $\approx 50 \mu m$
- analysis made 2 mm before channel exit
- but channel seems uniform
- density where guiding was obtained

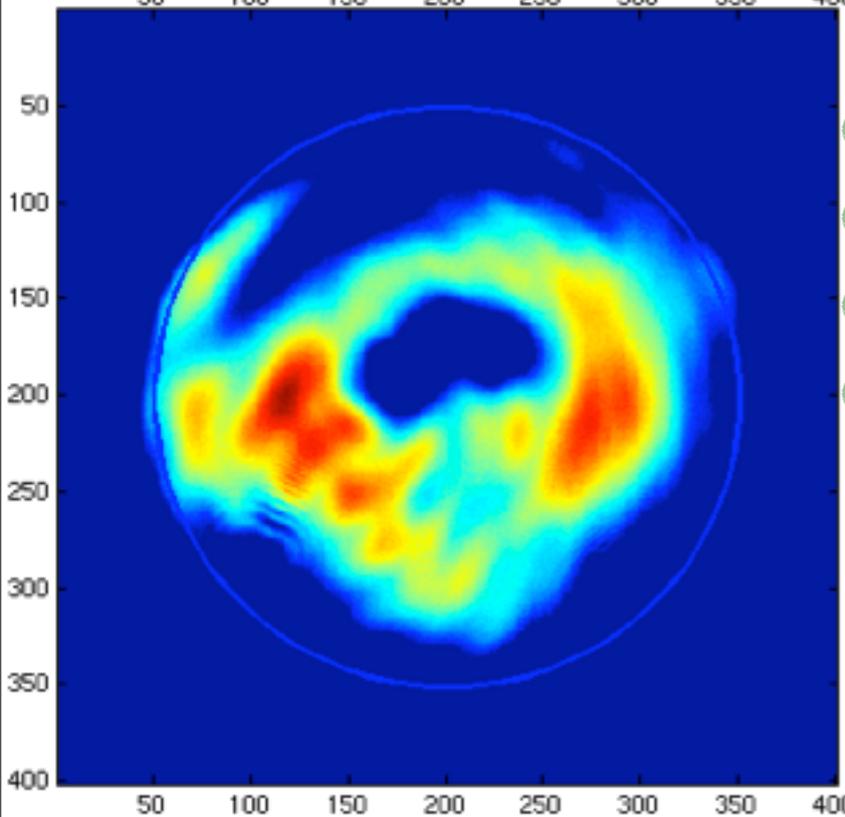
# Experimental results - Low power guiding



- focal spot
- channel entrance
- no discharge
- no gas
- image made through cell apertures
- no filter



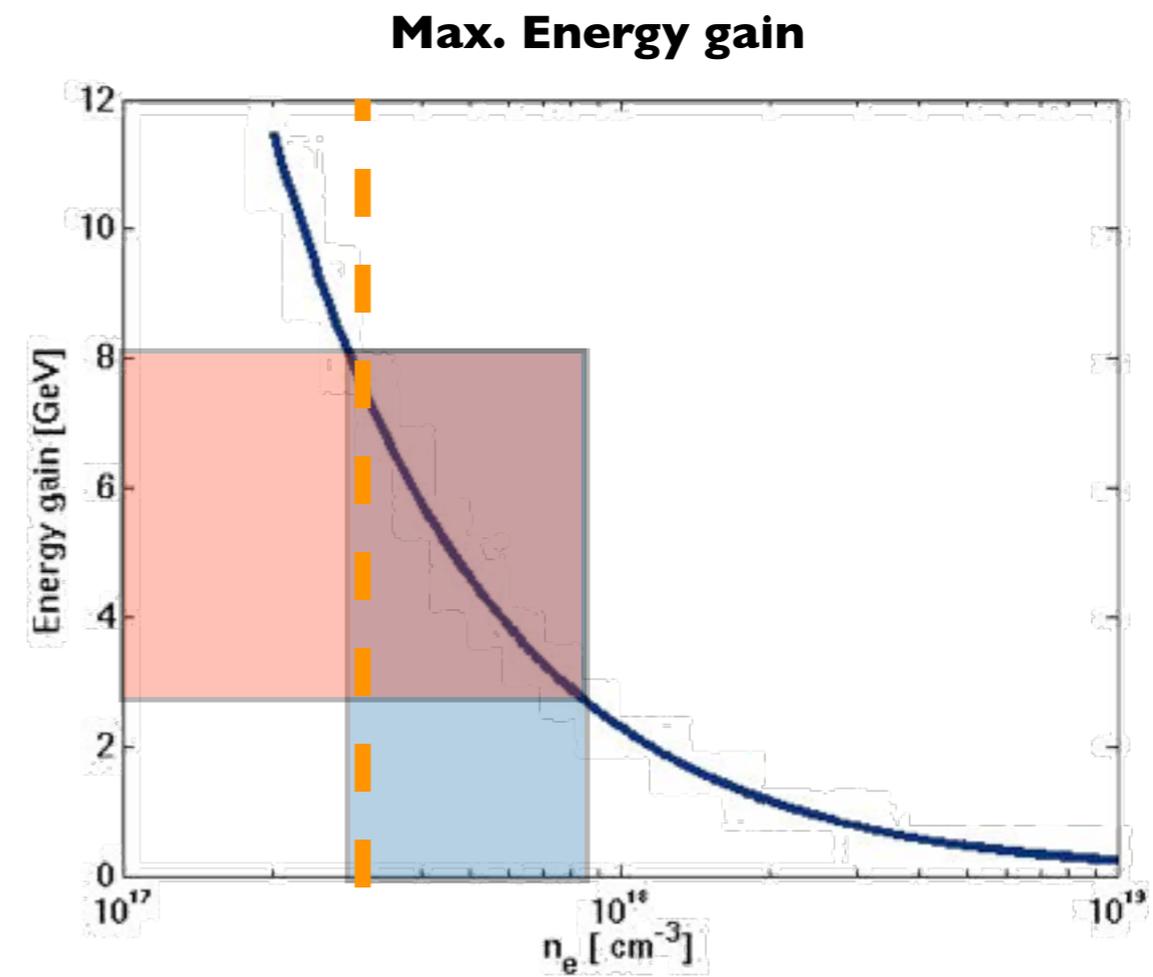
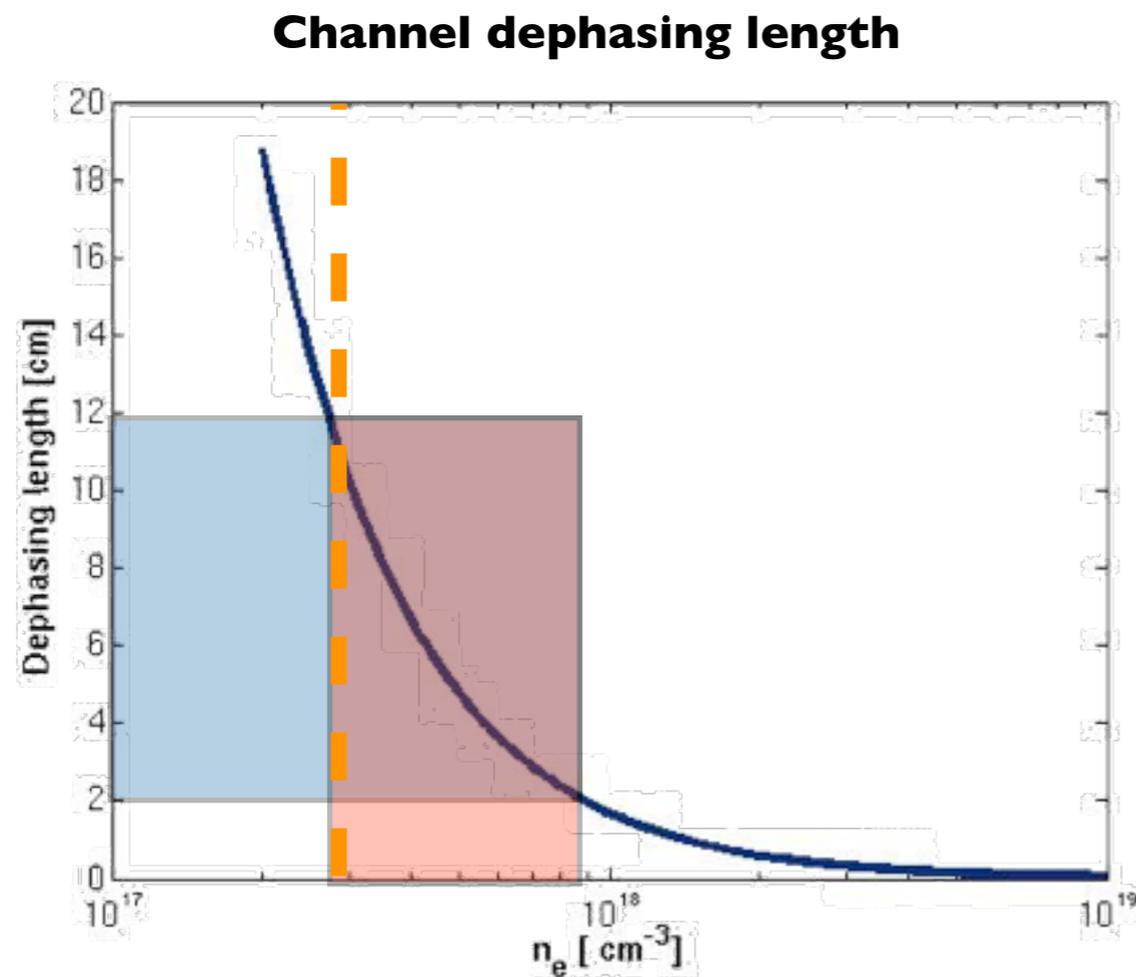
- channel exit
- discharge
- gas
- ND filter 0.4
- typical shot



- channel exit
- no discharge
- gas
- no filter

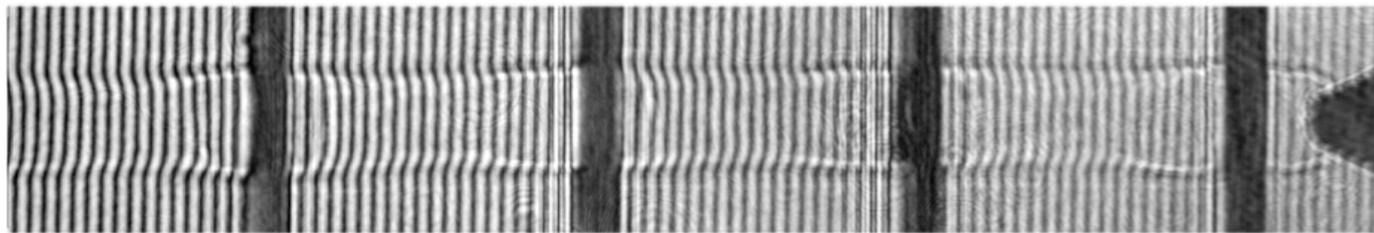
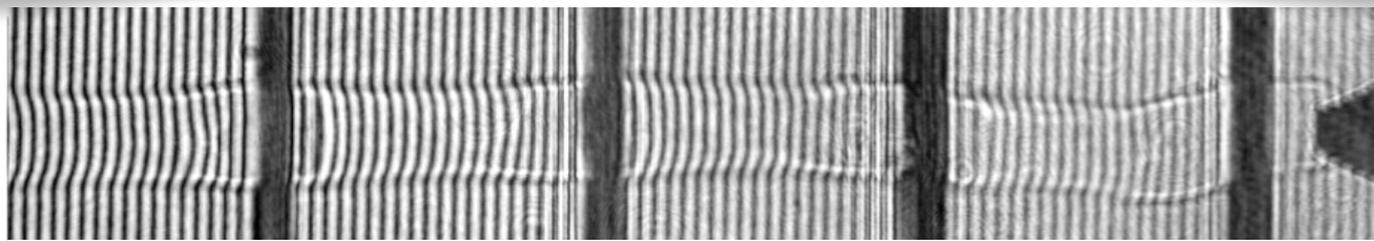
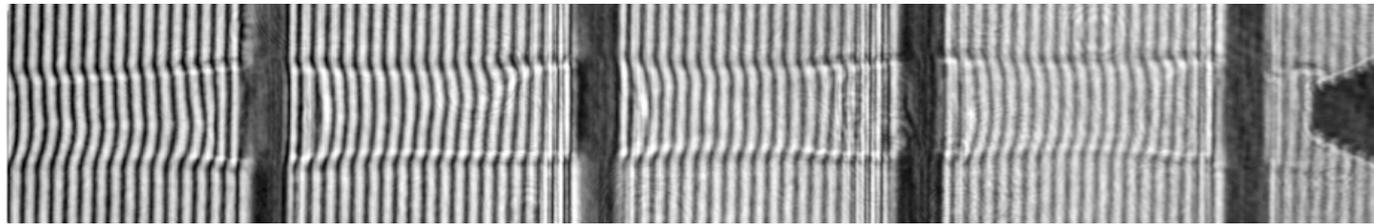
- Beam diam. 30 mm
- F. distance 1 m
- Gauss. spot radius 44  $\mu\text{m}$
- R. Length 1.5 mm
- Channel length 16 mm

# Experimental results - e<sup>-</sup> acceleration prospects



- dephasing length is  $\sim 11$  cm
- max. energy gain (for the deph. length)  $\sim 8$  GeV
- plasma wall  $\Delta n_e \sim 10^{18}$  cm<sup>-3</sup>, channel radius  $\sim 500$   $\mu$ m
- matched prop. spot radius  $\sim 45$   $\mu$ m
- requires laser pulse with  $\sim 10$  J, 70 fs

# Reproducibility/symmetry/uniformity issues



obtained with HV magnetic compression  
( $<4$  ns voltage risetime)

## Problem

- deeper channels require short HV rise-times and higher currents
- short rise-times strongly increase the probability of hot-spots and non-uniform/non-reproducible plasmas

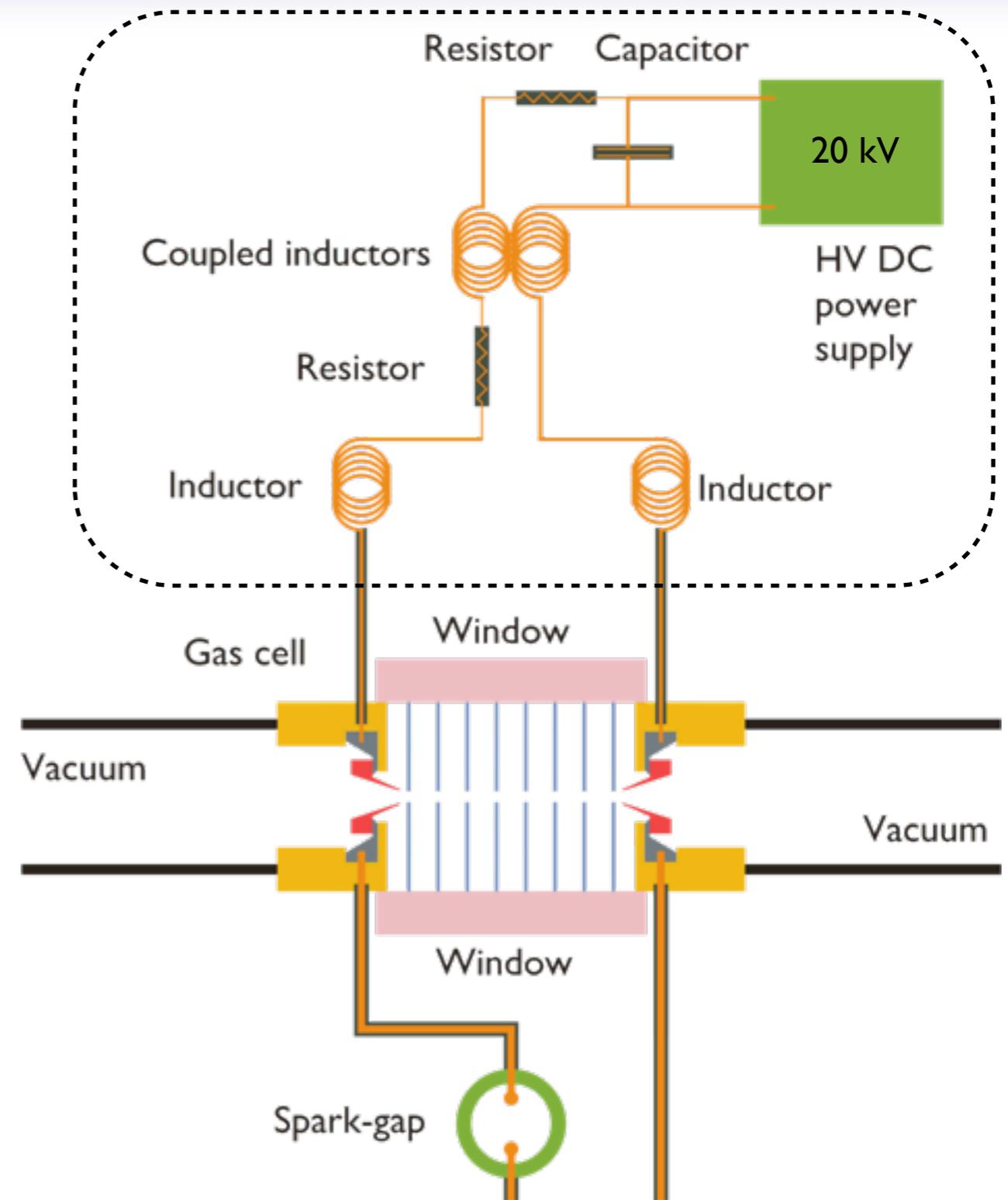
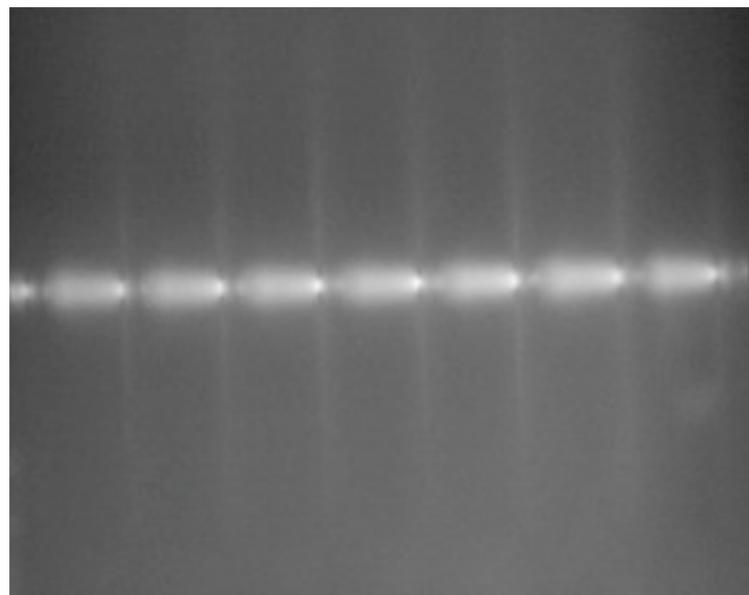
## Solution

- produce the main discharge over a partially ionized uniform gas background

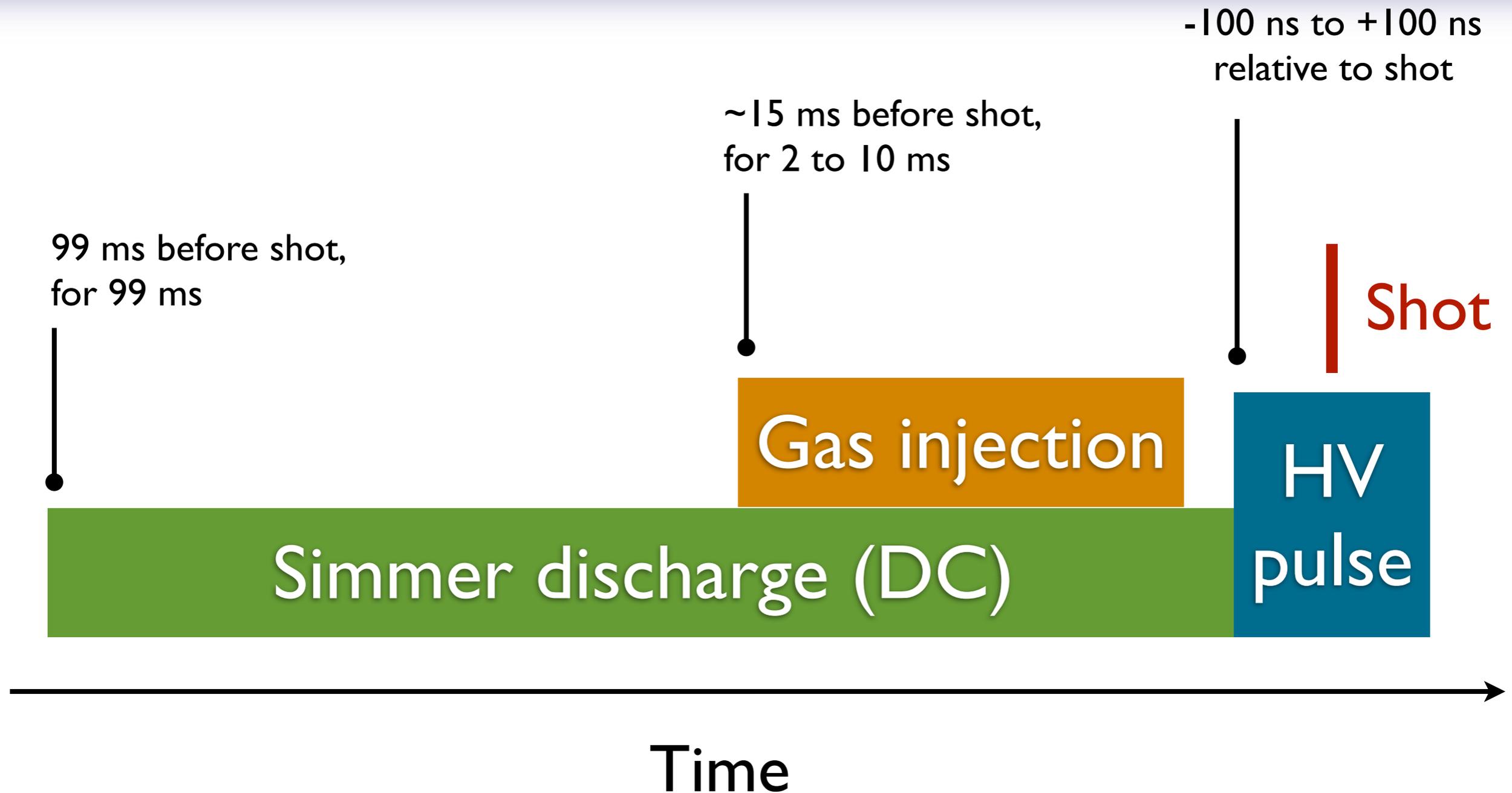
# Electric setup for a glow pre-discharge

## 📌 Simmer discharge (DC)

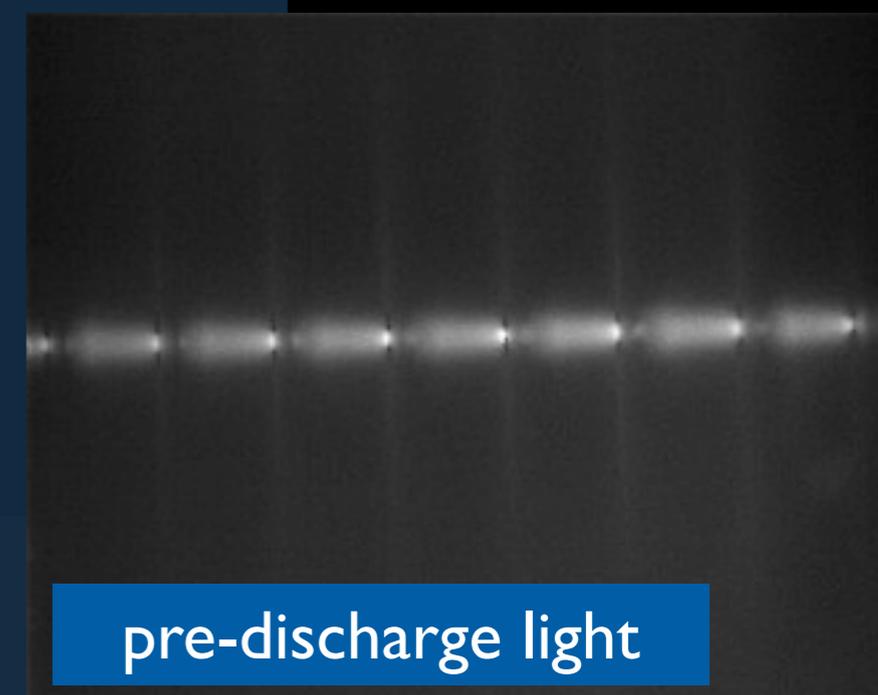
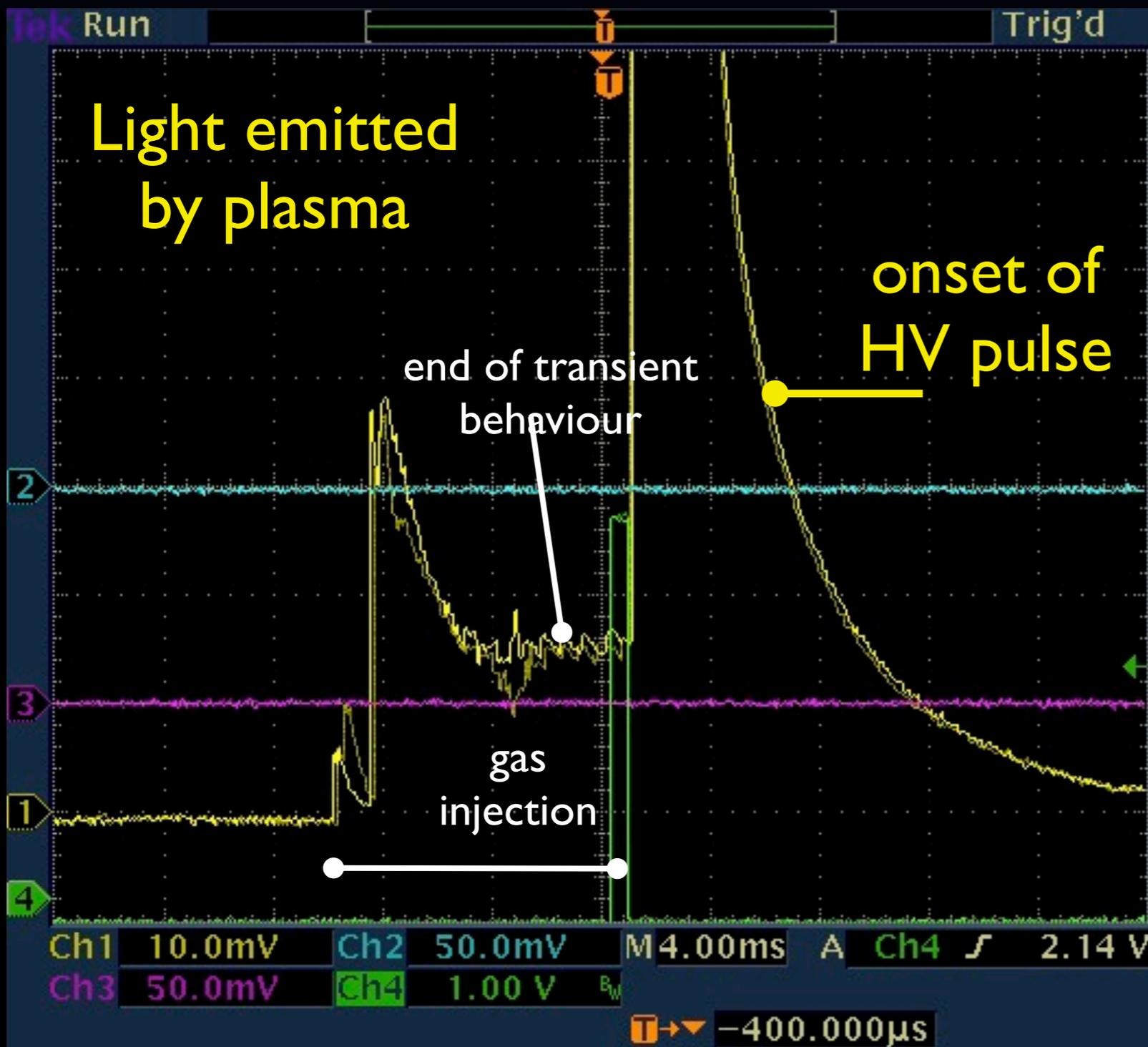
- 20 kV power supply
- slow rise time (ms)
- inductors block main HV pulse
- resistor limits current ( $R = 20\text{ M}\Omega$ ) to  $\sim 1\text{ mA}$



# Time sequence with pre-discharge



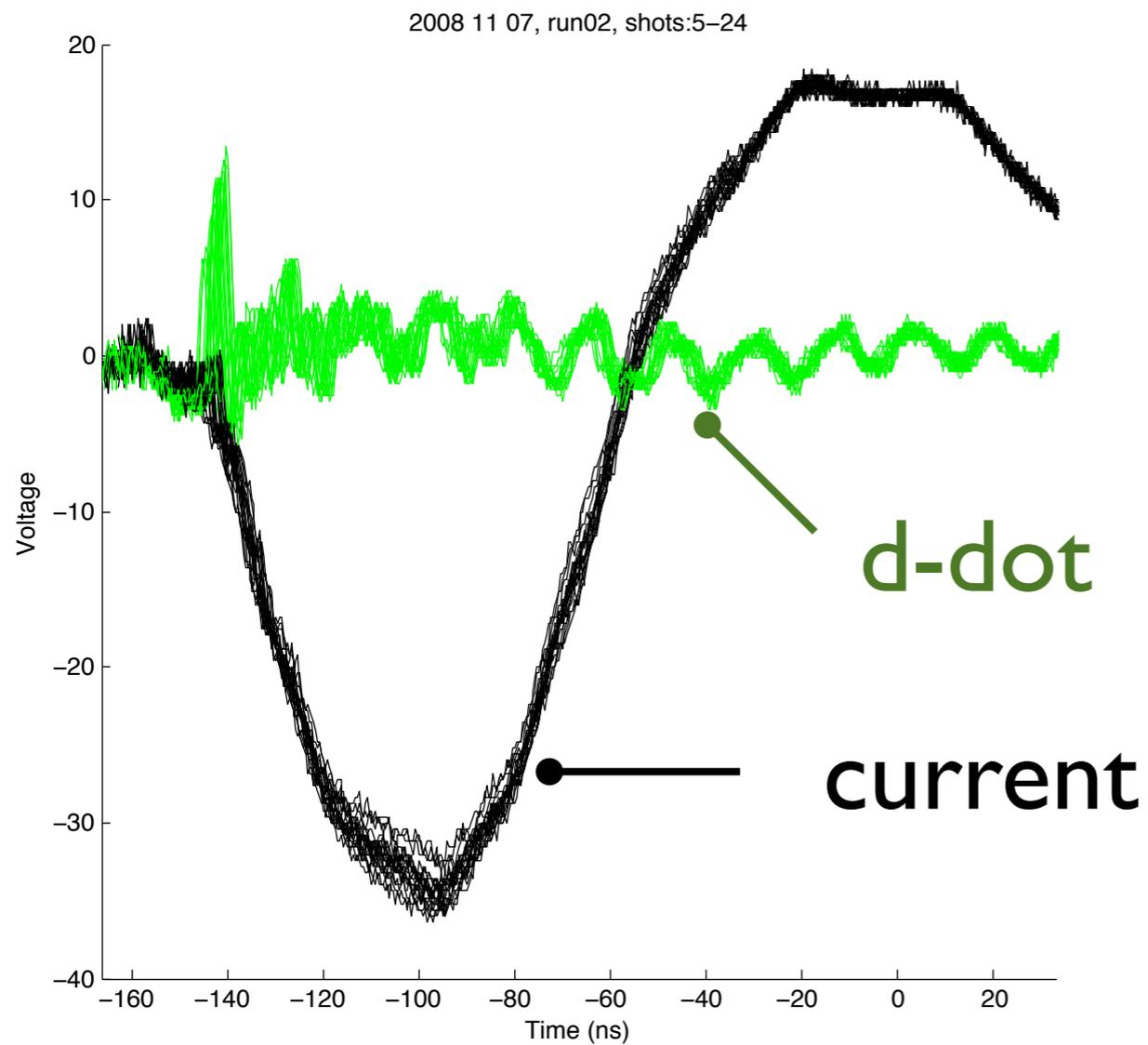
# Pre-discharge signature



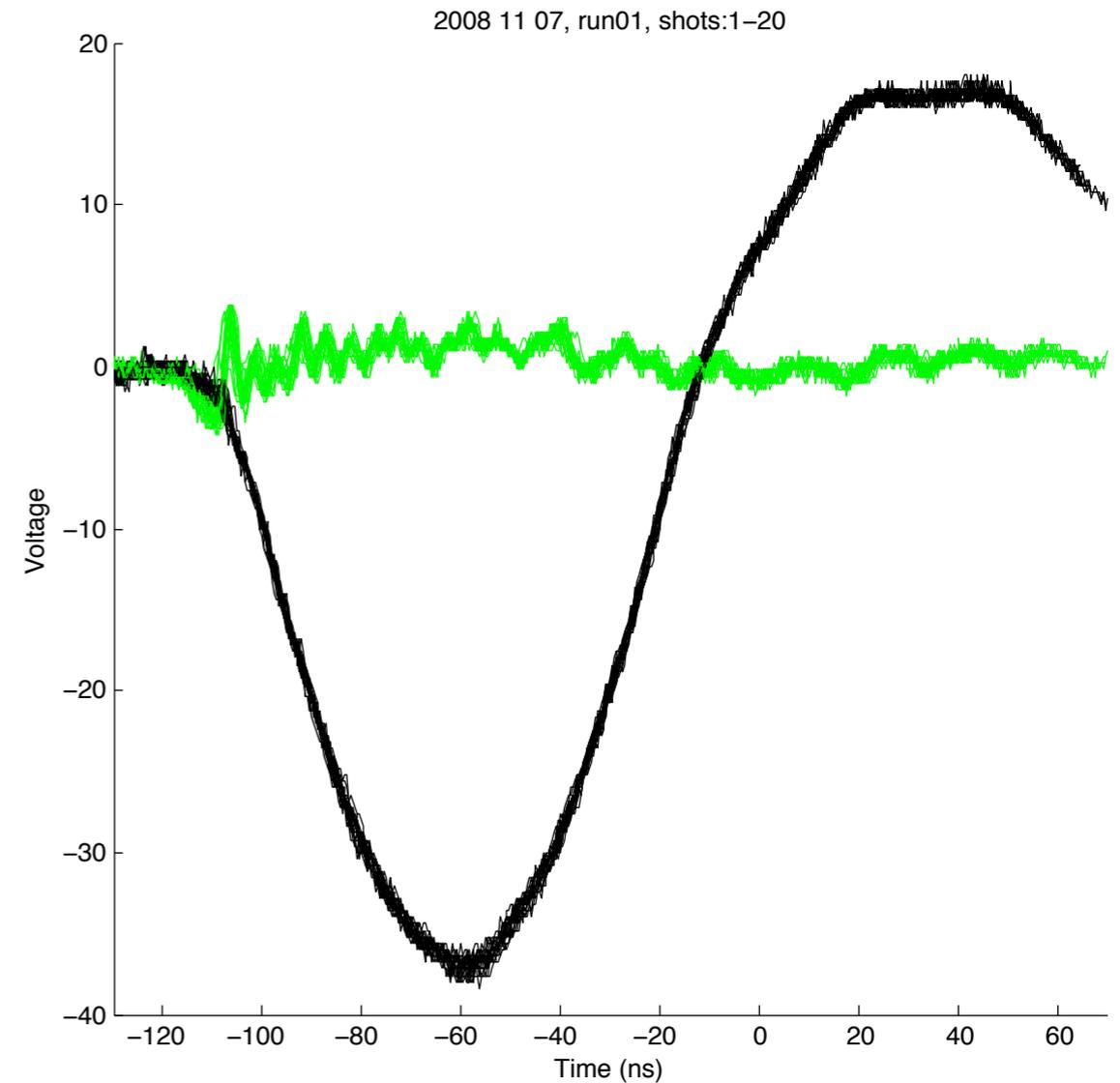
# Reproducible and smooth discharges

Overlapping 20 consecutive shots

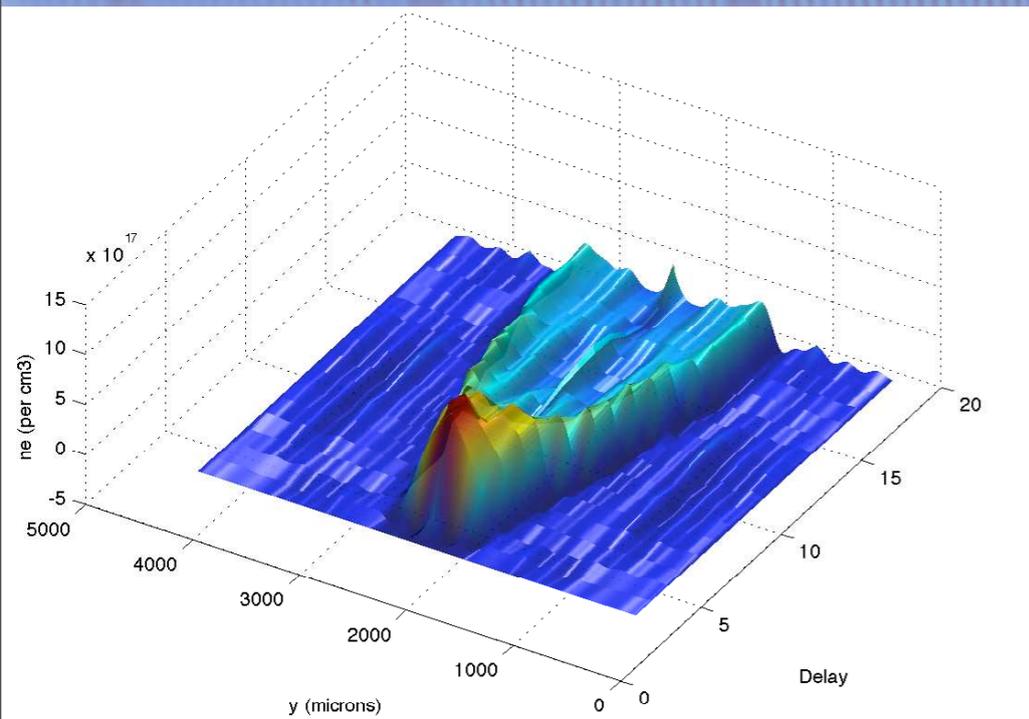
## HV pulse only



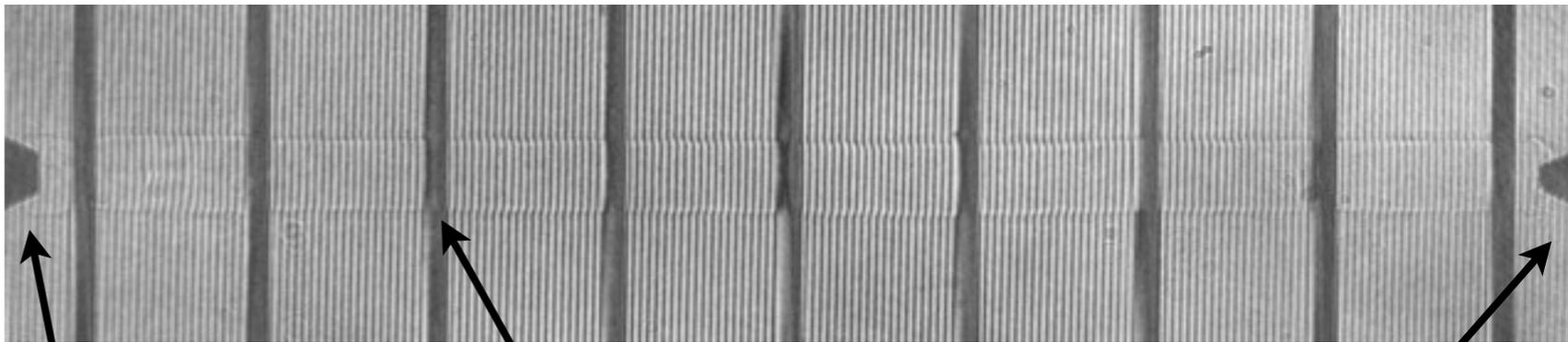
## HV + simmer discharge



# Reproducible and smooth plasma channels



Expansion rate:  $\sim 800 \text{ m s}^{-1}$



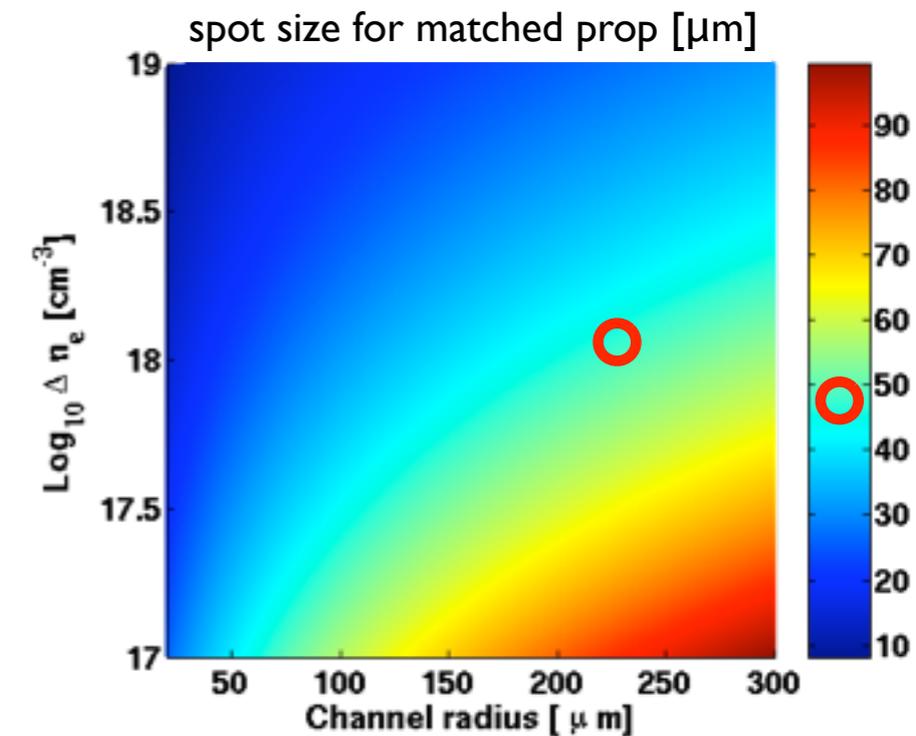
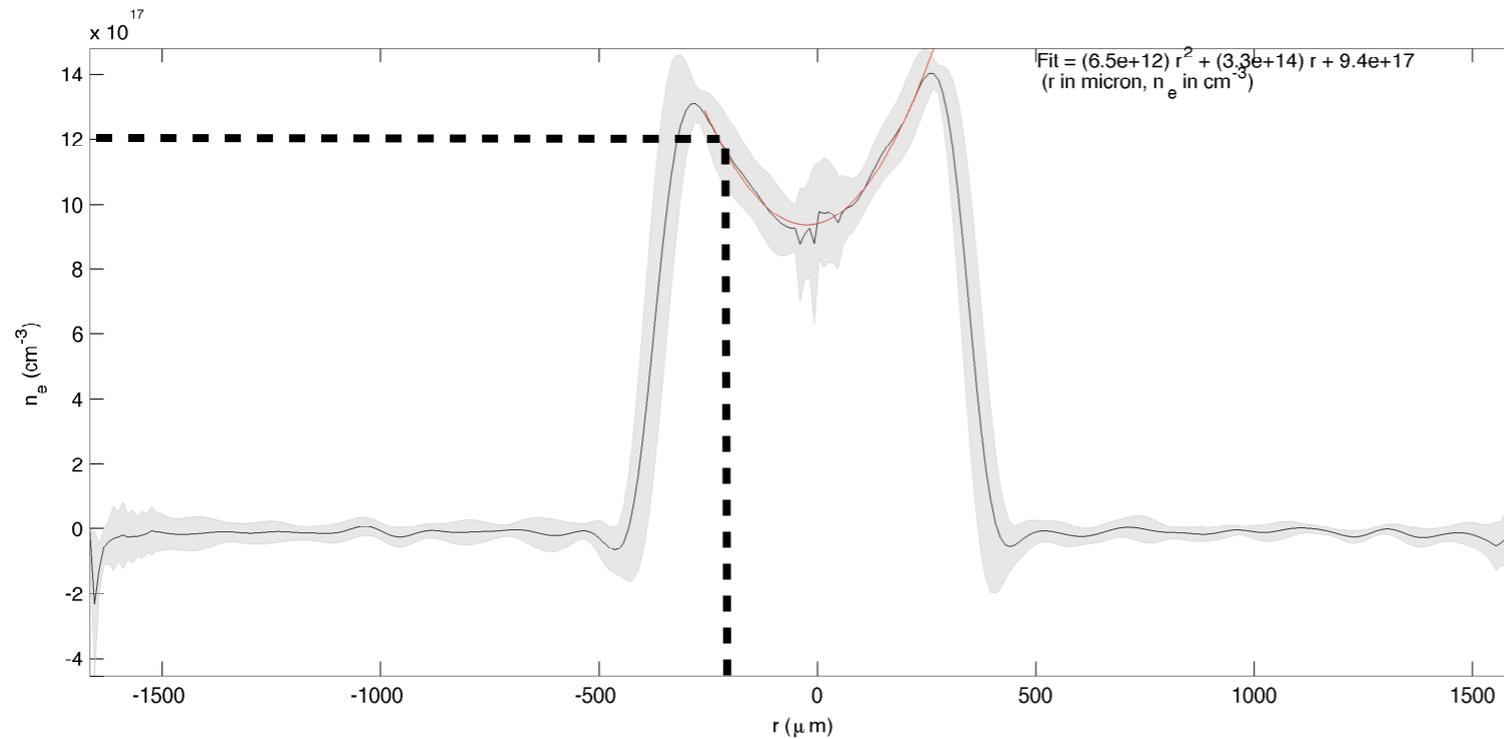
300  $\mu\text{m}$  diameter  
electrode

150  $\mu\text{m}$  diameter  
dielectric apertures

125  $\mu\text{m}$  diameter  
electrode

- ▶ Pre-discharge allow for reproducible and symmetric plasma channels
- ▶ Was not possible to make guiding experiments (KA system required)
- ▶ Plasma channels seem to be robust enough to try increase the length of the gas cell approaching the dephasing length ( $\sim 10 \text{ cm}$ )

# Reproducible and smooth plasma channels



▶ matched guiding for 40-50  $\mu\text{m}$  spot sizes

▶  $n_{e0} = 10^{18} \text{ cm}^{-3}$

▶ 5J Laser requires

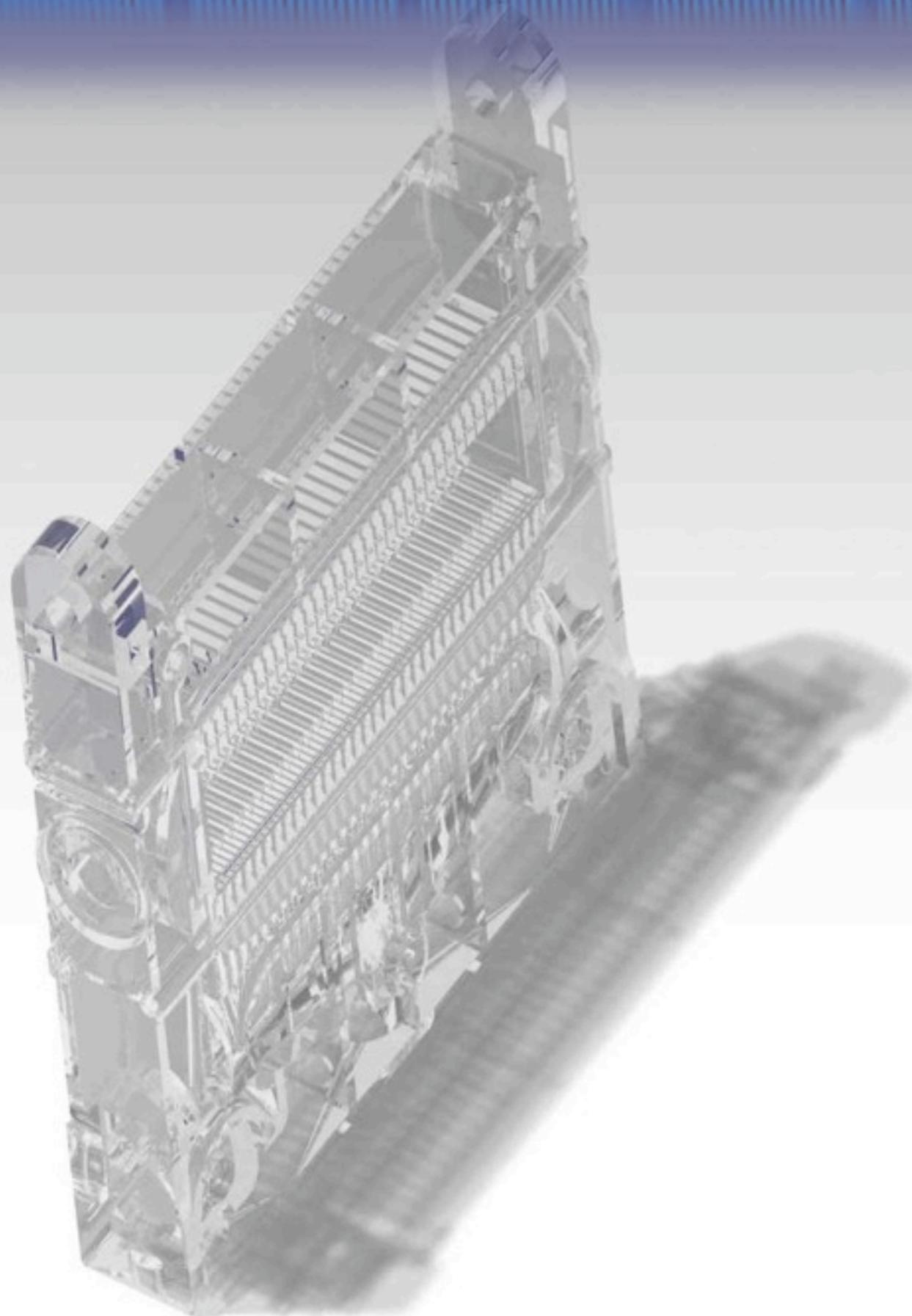
▶  $n_{e0} = 3.5 \times 10^{17} \text{ cm}^{-3}$

▶ spot size 25  $\mu\text{m}$

▶ length 10 cm

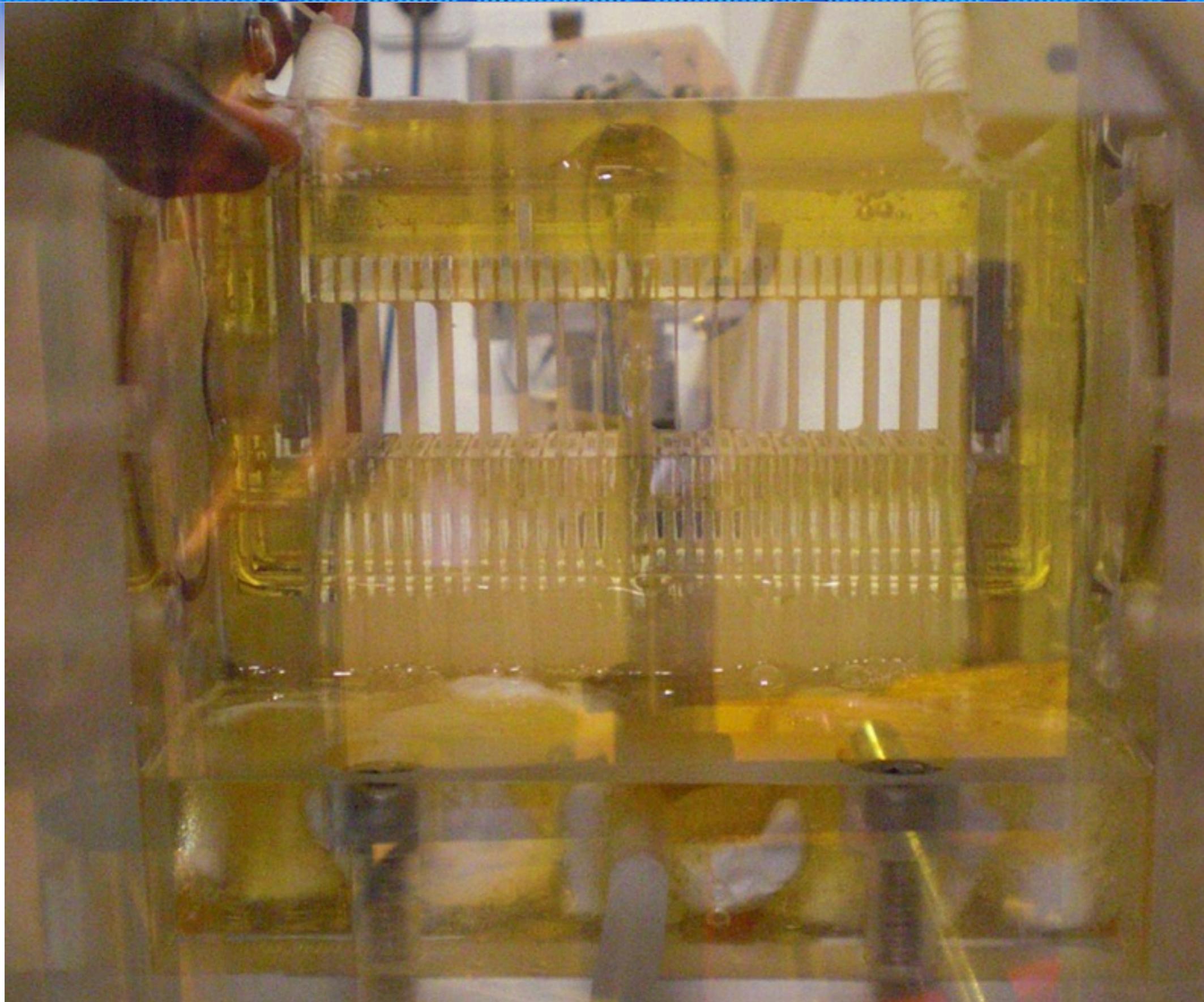
▶ Next experiment will try to reach these goals with a new pulser with  $>2 \text{ kA}$  discharge

# 8 cm long structured gas cell



- ▶ 8cm: a compromise to between what we now (2 cm) and what we need (12 cm)
- ▶ 150 micron apertures: decrease the plasma diameter
- ▶ duplicate the length of the cells 2.5 mm → 5mm
- ▶ increase the height of the dielectric apertures: reduce parasitic discharges
  
- ▶ Goal: a step forward on a plasma cell we could use w/ advantage in current systems

# 8 cm long structured gas cell



# 8 cm long structured gas cell

- ▶ Parasitic discharges always present and more important
- ▶ Plasma not heated to full ionization
- ▶ Expansion not resulting in a plasma channel
- ▶ Paschen curves do not apply due to the sequence of small apertures
- ▶ 0.25 T longitudinal B field did not change the behavior

## Rescue in progress

- ▶ to pulse the DC discharge - start on more favorable pressure
- ▶ increase the DC voltage from 14 kV to 40 kV
- ▶ increase complexity of gas cell (may reduce gas pressure uniformity)
- ▶ increase B Field (require embedded coils and high current pulse)
- ▶ trigger the plasma w/ a ~100 KeV electron beam (€, long term project)

# Conclusions

- ▶ convincing demo for 2 cm plasma channels (quality, reproducibility)
- ▶ easy path for at least 4 cm channels
- ▶ easy (but not inexpensive) path for 10 Hz use
- ▶  $>40 \mu\text{m}$  spot size matched propagation (more work needed to reduce it)
- ▶ current versions compatible with  $> \text{GeV}$   $e^-$  beams
- ▶ system is working now inside a metallic big vacuum chamber

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